Requester's Full Name: DAWN GARRETT Examiner #: 76107 Date: 8/3/2004 Art Unit: 1774 Phone Number 22-1523 Serial Number: 10/642,697 Mail Box and Bldg/Room Location: Results Format Preferred (circle): PAPER DISK E-MAIL Remsen 5C75
If more than one search is submitted, please prioritize searches in order of need.
Please provide a detailed statement of the search topic, and describe as specifically as possible the subject matter to be searched. Include the elected species or structures, keywords, synonyms, acronyms, and registry numbers, and combine with the concept or utility of the invention. Define any terms that may have a special meaning. Give examples or relevant citations, authors, etc, if known. Please attach a copy of the cover sheet, pertinent claims, and abstract.
Title of Invention: Film for Organic El Denie And An Organic Derice Using the Film
inventors (please provide full names).
YUICHI SAWAI, TOMOSI OISHI, YOSHIYUKI KANEKO,
Earliest Priority Filing Date: 3/5/2001 (JP 2001 - 060446)
For Sequence Searches Only Please include all pertinent information (parent, child, divisional, of issued patent numbers) along with the
us 20040053040 6638645
Please search the hybrid felm comprising
An organic morety and inoganic sheletal morety of cl. 1
Mis Specifically search:
hybrid film of cl. 2 comprising polychlorofluoroethylane harring a silvxane grup
$\Lambda_{\sim 10}$
hybrid film of cl. 3 comprising
fluorine group and silvane group
Thanh you.
STAFF USE ONLY Type of Search Vendors and cost where applicable
Searcher: NA Sequence (#) STN 4 30 68
Searcher Phone #: AA Sequence (#) Dialog
Searcher Location: Structure (#) Questel/Orbit
Date Searcher Picked Up: Bibliographic Dr.Link
Date Completed: Litigation Lexis/Nexis

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=> file hca
=> d his
     (FILE 'HOME' ENTERED AT 08:35:33 ON 12 AUG 2004)
     FILE 'HCA' ENTERED AT 08:36:37 ON 12 AUG 2004
                E US20040053070/PN
L1
              1 S E3
                SEL L1 RN
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L2
              9 S E1-E9
                E F/PCT
L3
           9720 S E5
           1162 S L3 AND 1-10/SI
L4
     FILE 'HCA' ENTERED AT 08:39:27 ON 12 AUG 2004
L5
          73235 S L3
L6
            398 S L4
L7
         604372 S EL OR E(W)L OR ELECTROLUM!N? OR ORGANOLUM!N? OR (ELECTRO OR O
^{\text{L8}}
         110655 S EL OR E(W)L OR ELECTROLUM!N? OR ORGANOLUM!N? OR (ELECTRO OR O
L9
              2 S L6 AND L8
            675 S L5 AND L8
L10
         719365 S ELECTRODE? OR ANODE? OR CATHODE?
L11
L12
           136 S L10 AND L11
L13
                QUE FILM? OR THINFILM? OR LAYER? OR OVERLAY? OR OVERLAID? OR LA
L14
           4283 S L13(2N) HYBRID?
              0 S L10 AND L14
L15
             62 S L8 AND L14
L16
L17
             18 S L14(2N)L8
L18
              4 S L17 AND L11
L19
          91081 S SILOXANE?
            355 S FLUROPOLYMER### OR CHLOROPOLYMER### OR HALOPOLYMER####
L20
L21
              0 S L17 AND L19
L22
              0 S L17 AND L20
        1137470 S ORGANIC? OR INORGANIC?
L23
L24
             13 S L17 AND L23
L25
           4047 S ITO#(2N)L11
L26
          17078 S ITO#
L27
              8 S L16 AND L26
              0 S L17 AND L26
L28
             5 S L16 AND L25
L29
             26 S L17 OR L18 OR L27 OR L29
L30
             13 S L30 AND 1907-2001/PY, PRY
L31
             35 S L16 AND 1907-2001/PY, PRY
L32
            17 S L30 AND 1907-2002/PY, PRY
L33
             22 S L32 NOT L33
L34
             9 S L30 NOT L33
L35
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     FILE 'WPIX' ENTERED AT 08:51:00 ON 12 AUG 2004
         227157 S L8 OR EL
L36
L37
           1907 S L13(2N) HYBRID?
L38
             33 S L36 AND L37
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1900006 S 11 OR ELECTRODE
        4224 S ITO#
L40
            10 S L38 AND L39
L41
             1 S L38 AND L40
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            17 S L38 AND 2003-2004/PY, PRY
L43
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            10 S L41 OR L42
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L47
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L49
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L50
L51
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           6585 S ITO#
L53
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L54
        620331 S L11 OR ELECTRODE
     FILE 'JAPIO' ENTERED AT 09:00:38 ON 12 AUG 2004
L55
      473252 S L11
             0 S L51 AND L53
L56
             4 S L51 AND L55
L57
            10 S L51 OR L57
L58
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L59
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L60
         5737 S L13(2N) HYBRID?
           73 S L59 AND L60
L61
         314474 S L11 OR ELECTRODE
L62
L63
         12095 S ITO#
L64
         117501 S LED#
L65
         222332 S L64 OR L59
           130 S L65 AND L60
L66
             3 S L63 AND L66
L67
            14 S L62 AND L66
L68
        1285639 S POLYMER? OR ORGANIC? OR INORGANIC? OR OXIDE?
L69
L70
             41 S L66 AND L69
             13 S L70 AND OXIDE?
L71
            21 S L67 OR L68 OR L71
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L74
              SET MSTEPS ON
L75
            17 S L74
            22 S L74
L76
             9 S L74
L77
            48 FILE HCA
L78
L79
             3 S L74
            12 S L74
L80
L81
            15 FILE WPIX
L82
             9 S L74
             9 FILE JAPIO
L83
             7 S L74
L84
             7 FILE COMPENDEX
L85
            4 S L74
L86
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L87 4 FILE INSPEC
TOTAL FOR ALL FILES
L88 83 S L74 AND (L8 OR LED)

FILE 'LCA' ENTERED AT 09:12:50 ON 12 AUG 2004

FILE 'HCA' ENTERED AT 09:13:18 ON 12 AUG 2004

FILE 'WPIX' ENTERED AT 09:14:40 ON 12 AUG 2004

FILE 'JAPIO' ENTERED AT 09:16:24 ON 12 AUG 2004

FILE 'COMPENDEX, INSPEC' ENTERED AT 09:19:24 ON 12 AUG 2004

FILE 'HCA' ENTERED AT 09:23:30 ON 12 AUG 2004

FILE 'HCA' ENTERED AT 09:13:18 ON 12 AUG 2004
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FILE COVERS 1907 - 5 Aug 2004 VOL 141 ISS 7 FILE LAST UPDATED: 5 Aug 2004 (20040805/ED)

This file contains CAS Registry Numbers for easy and accurate substance identification.

=> d L33 1-17 cbib abs hitind hitrn

L33 ANSWER 1 OF 17 HCA COPYRIGHT 2004 ACS on STN

140:243688 Transparent electroconductive films, flexible display panels, touch panels, and organic-inorganic hybrid polymer films
therefor. Okubo, Yasushi; Takagi, Takahiro; Kurachi, Ikuo (Konica Minolta Holdings Inc., Japan). Jpn. Kokai Tokkyo Koho JP 2004075951 A2 20040311,
33 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 2002-241869 20020822.

AB The hybrid films comprise cellulase esters and metal compds. ApMqBr (M = metal; A, B = unhydrolyzable and hydrolyzable substituent resp.) undergoing hydrolysis to give 0.1 40% (to the film)

substituent, resp.) undergoing hydrolysis to give 0.1-40% (to the film) ApMqOr/2. The cellulose esters may satisfy 1.0< X + Y <2.5 and 0< X <2.5 (X, Y = degree of acetylation and that of other esterification, resp.). The transparent electroconductive films comprise the hybrid films having moisture-barrier metal oxide (or nitride) layers and transparent elec. conductive layers. Flexible transparent electrode substrates with high Tg and low birefringence are

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10/642,697 D. Garrett afforded as above. ICM C08L001-14 IC B32B007-02; B32B009-00; B32B023-20; C08J005-18; C08L083-04; C08L085-00; G02B001-10; H01B005-14; H01H001-02 74-13 (Radiation Chemistry, Photochemistry, and Photographic and Other CC Reprographic Processes) Section cross-reference(s): 38, 76 transparent ITO substrate cellulose silicate hybrid; flexible STzirconate aluminate hybrid cellulose LCD substrate; LED touch panel substrate cellulose inorg hybrid Electroluminescent devices IT(displays, organic; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays) Transparent films IT(elec. conductive; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays) Luminescent screens ΙT (electroluminescent, organic; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays) Electric conductors ΙT (films, transparent; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays) Nitrides ITOxides (inorganic), preparation RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (moisture-barrier layers; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays) Liquid crystal displays IT Nanocomposites (organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays) TT Silsesquioxanes RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (silicate-, nanocomposites; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays) ITSilicates, preparation RL: DEV (Device component use); IMF (Industrial manufacture); TEM

(Technical or engineered material use); PREP (Preparation); USES (Uses) (silsesquioxane-, nanocomposites; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays)

ΙT Optical imaging devices

(touch panels; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays)

9004-39-1, Cellulose acetate propionate ΤТ RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(CAP, substrates; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible **ITO** substrates of flat panel displays)

IT 9035-69-2, Diacetyl cellulose

RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(Daicel LM 80, Daicel L 50, nanocomposites; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays)

IT 9012-09-3P, Triacetyl cellulose

RL: IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(Daicel LT 55, substrates; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays)

IT 7631-86-9P, Silica, preparation

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (moisture-barrier layers; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays)

IT 2269-22-9P 11099-06-2P, Ethyl silicate 39317-21-0P, Zirconium tetrapropoxide homopolymer 53339-36-9P, Titanium tetraisopropoxide homopolymer 88029-70-3P, Methyltriethoxysilane-tetraethoxysilane copolymer

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (nanocomposites; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays)

IT 50926-11-9P, Indium tin oxide

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (transparent electrode layers; organic-inorg. nanocomposite films with prescribed amount of hydrolyzed metal alkoxides for flexible ITO substrates of flat panel displays)

- L33 ANSWER 2 OF 17 HCA COPYRIGHT 2004 ACS on STN
- 139:108335 Hybrid electroluminescent devices with atomic layer deposited thin films on a screen printed dielectric. Stuyven, Gert; De Visschere, Patrick; Neyts, Kristiaan; Hikavyy, Andriy (Electronics and Information Systems Department, Ghent University, Ghent, B-9000, Belg.). Japanese Journal of Applied Physics, Part 1: Regular Papers, Short Notes & Review Papers, 41(9), 5702-5705 (English) 2002. CODEN: JAPNDE. Publisher: Japan Society of Applied Physics.
- AB A hybrid electroluminescent (EL) device structure was developed, consisting of a screen printed Pt/Ag conductor and high-k BaTiO3 dielec., on which a phosphor, a thin insulator and a transparent conductor were deposited by atomic layer deposition (ALD). The use of the hybrid EL structure results in more than a doubling of brightness compared with the thin-film EL alternative structure. While hybrid EL devices with ALD-grown thin-film stack deposited directly on top of a rough dielec. yield a uniform light emission, the aging stability is determined largely by the occurrence of local breakdown events due to elec. field inhomogeneities originating from the combination of the rough BaTiO3/ZnS:Mn interface and the high dielec. constant of BaTiO3. Nevertheless, lifetimes of more than 600 h at 1 kHz could be obtained.
- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related

D. Garrett

Properties)
Section cross-reference(s): 66, 76

IT Atomic layer epitaxy Screen printing

Semiconductor device fabrication

(hybrid electroluminescent devices with atomic layer deposited thin films on screen printed dielec.)

7440-06-4, Platinum, uses 7440-22-4, Silver, uses
RL: DEV (Device component use); PEP (Physical, engineering or chemical process); PYP (Physical process); PROC (Process); USES (Uses)

(contact layer; hybrid electroluminescent devices with atomic layer deposited thin films on screen printed dielec.)

L33 ANSWER 3 OF 17 HCA COPYRIGHT 2004 ACS on STN

138:14200 Synthesis and Characteristics of Poly[N,N'-diphenyl-N,N'-bis(4-aminobiphenyl)-(1,1'-biphenyl)-4,4'-diamine pyromellitimide] as a Hole Injecting and Transporting Layer for Hybrid Organic Light-Emitting Device. Kim, Youngkyoo; Han, Kijong; Ha, Chang-Sik (New Electroluminescent Systems Center, Institute for Advanced Engineering (IAE), Kyounggi-Do, 449-860, S. Korea). Macromolecules, 35(23), 8759-8767 (English) 2002. CODEN: MAMOBX. ISSN: 0024-9297. Publisher: American Chemical Society.

AB A hole injection and transport layer polymer, poly[N,N'-diphenyl-N,N'-bis(4-aminobiphenyl)-(1,1'-biphenyl)-4,4'-diamine pyromellitimide]
(PMDA-DBABBD PI), was prepared by thermal imidization of the poly(amic acid)
(PAA), which in term was prepared by polymerization of pyromellitic dianhydride with DBABBD. The DBABBD was prepared by reduction from

N,N'-diphenyl-N,N'-bis(4-nitrobiphenyl)-(1,1'-biphenyl)-4,4'-diamine, via palladium-catalyzed amination. The polyimide (PI) was characterized by 1H NMR, 13C NMR, FTIR, HR GC-MS, EA, and DSC methods. The characteristics of the PAA and PI thin films were studied by XPS and impedance spectroscopy. The PAA and PI thin films were assembled into hybrid organic electroluminescent device structures (HOLED) to examine the performance as hole injection and transport layer. The PI thin film having glass transition temperature of 200° showed stable characteristics suitable for application in HOLED whereas PAA thin films were unstable. The power efficiency of HOLED with PI thin film was

CC 35-5 (Chemistry of Synthetic High Polymers) Section cross-reference(s): 36, 73

IT 7429-90-5, Aluminum, uses 12798-95-7

RL: DEV (Device component use); USES (Uses)

(electrode layer; preparation and NMR spectra and optical properties of poly[N,N'-di-Ph-N,N'-bis(aminobiphenyl)-(biphenyl)diamine pyromellitimide] as hole injection layer in hybrid organic LEDs)

IT 50926-11-9, Indium-tin oxide

0.23 cd/A at 4000 cd/m2.

RL: DEV (Device component use); NUU (Other use, unclassified); USES (Uses) (substrate and electrode layer; preparation and NMR spectra and optical properties of poly[N,N'-di-Ph-N,N'-bis(aminobiphenyl)- (biphenyl)diamine pyromellitimide] as hole injection layer in hybrid organic LEDs)

L33 ANSWER 4 OF 17 HCA COPYRIGHT 2004 ACS on STN

137:223924 Environmental barrier materials for encapsulated organic light-emitting devices. Graff, Gordon L.; Gross, Mark E.; Affinito, John D.; Shi, Ming-Kun; Hall, Michael G.; Mast, Eric S.; Walty, Robert; Rutherford, Nicole; Burrows, Paul E.; Martin, Peter M. (USA). U.S. Pat. Appl. Publ. US 2002125822 Al 20020912, 10 pp.,

Cont.-in-part of U.S. Ser. No. 427,138. (English). CODEN: USXXCO. APPLICATION: US 2001-887605 20010622. PRIORITY: US 1998-212779 19981216; US 1999-427138 19991025.

Encapsulated organic light-emitting devices are described AB which comprise a substrate; an organic light-emitting device adjacent to the substrate; and ≥1 first barrier stack adjacent to the organic light-emitting device comprising ≥1 first barrier layer and ≥1 first decoupling layer, where the ≥1 first barrier stack encapsulates the organic light emitting device. Encapsulated organic lightemitting device are also described which comprise ≥1 s barrier stack comprising ≥ 1 s barrier layer and ≥ 1 s decoupling layer; an organic light-emitting device adjacent to the ≥1 s barrier stack; and ≥1 first barrier stack adjacent to the organic light-emitting device comprising ≥1 first barrier layer and ≥1 first decoupling layer, where the ≥ 1 first barrier stack and the ≥ 1 s barrier stack encapsulate the organic light-emitting devices.

IC ICM H01J001-62

NCL 313506000

CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related
Properties)
Section cross-reference(s): 76

ST environmental barrier org **light emitting** device packaging; barrier org LED encapsulation

IT Coating materials

(UV-absorbing, functional layer; environmental barrier materials for encapsulated organic light-emitting devices)

IT Coating materials

(anticorrosive, functional layer; environmental barrier materials for encapsulated organic light-emitting devices)

IT Coating materials

(antistatic, functional layer; environmental barrier materials for encapsulated organic light-emitting devices)

IT Cermets

(barrier layers; environmental barrier materials for encapsulated organic light-emitting devices)

IT Carbides

Metals, uses

Nitrides

Oxides (inorganic), uses

Oxynitrides

RL: DEV (Device component use); USES (Uses)

(barrier layers; environmental barrier materials for encapsulated organic light-emitting devices)

IT Polysiloxanes, uses

RL: DEV (Device component use); USES (Uses)

(carborane-, decoupling layers; environmental barrier materials for encapsulated organic light-emitting devices)

IT Silicates, uses

RL: DEV (Device component use); USES (Uses)

(decoupling layer; environmental barrier materials for encapsulated organic light-emitting devices)

IT Alkyd resins

Epoxy resins, uses

Phosphonitrile compounds

Polyamides, uses

Polyanilines

```
Polycarbonates, uses
     Polycarbosilanes
     Polyimides, uses
     Polyolefins
     Polyphosphazenes
     Polysilanes
     Polysiloxanes, uses
     Silazanes
     Siloxanes (nonpolymeric)
     Urethanes
     RL: DEV (Device component use); USES (Uses)
         (decoupling layers; environmental barrier materials for encapsulated
        organic light-emitting devices)
IT
     Coating materials
         (elec. conductive, functional layer; environmental barrier materials
        for encapsulated organic light-emitting devices)
ΙT
     Electroluminescent devices
         (encapsulation; environmental barrier materials for encapsulated organic
        light-emitting devices)
ΙT
     Electronic packages
     Electronic packaging materials
         (environmental barrier materials for encapsulated organic light-
        emitting devices)
IΤ
     Packaging materials
        (films, gas-impermeable; environmental barrier materials for
        encapsulated organic light-emitting devices)
IT
     Coating materials
        (fire-resistant, functional layer; environmental barrier materials for
        encapsulated organic light-emitting devices)
IT
     Glass substrates
        (flexible; environmental barrier materials for encapsulated organic
        light-emitting devices)
IT
     Adhesives
     Antireflective films
        (functional layer; environmental barrier materials for encapsulated
        organic light-emitting devices)
TT
     Polymers, uses
     RL: DEV (Device component use); USES (Uses)
        (metal-containing, decoupling layer; environmental barrier materials for
        encapsulated organic light-emitting devices)
IT
     Borides
     RL: DEV (Device component use); USES (Uses)
        (oxyborides, barrier layers; environmental barrier materials for
        encapsulated organic light-emitting devices)
IΤ
     Polyethers, uses
     RL: DEV (Device component use); USES (Uses)
        (polyarylethers, decoupling layers; environmental barrier materials for
        encapsulated organic light-emitting devices)
IΤ
     Hybrid organic-inorganic materials
        (polymer-silica hybrid decoupling layers;
        environmental barrier materials for encapsulated organic light-
        emitting devices)
IΤ
     Coating materials
        (scratch-resistant, functional layer; environmental barrier materials
        for encapsulated organic light-emitting devices)
IT
     RL: DEV (Device component use); USES (Uses)
        (siloxane-, decoupling layers; environmental barrier materials for
```

encapsulated organic light-emitting devices) IT Polymers, uses RL: DEV (Device component use); USES (Uses) (substrate, decoupling layer; environmental barrier materials for encapsulated organic light-emitting devices) IT Ceramics Semiconductor materials (substrate; environmental barrier materials for encapsulated organic light-emitting devices) 409-21-2, Silicon carbide, uses 1312-43-2, Indium oxide 1332-29-2, Tin IT1344-28-1, Alumina, uses 7631-86-9, Silica, uses 11105-01-4, Silicon nitride oxide 12033-89-5, Silicon nitride, uses 13463-67-7, Titania, uses 24304-00-5, Aluminum nitride 50926-11-9, ITO RL: DEV (Device component use); USES (Uses) (barrier layers; environmental barrier materials for encapsulated organic light-emitting devices) 1313-96-8, Niobium oxide 1313-99-1, Nickel oxide, uses 1314-13-2, Zinc oxide, uses 1314-23-4, Zirconium oxide, uses 1314-35-8, Tungsten oxide, uses 1314-36-9, Yttrium oxide, uses 1314-61-0, Tantalum oxide 7429-90-5, Aluminum, uses 7440-02-0, Nickel, uses 7440-03-1, Niobium, uses 7440-25-7, Tantalum, uses 7440-31-5, Tin, uses 7440-32-6, Titanium, uses 7440-33-7, Tungsten, uses 7440-42-8, Boron, uses 7440-47-3, Chromium, uses 7440-58-6, Hafnium, uses 7440-65-5, Yttrium, 7440-66-6, Zinc, uses 7440-67-7, Zirconium, uses 7440-74-6, Indium, uses 10043-11-5, Boron nitride, uses 11118-57-3, Chromium oxide 12055-23-1, Hafnium oxide 12069-32-8, Boron carbide 12070-12-1, Tungsten carbide 12633-97-5, Aluminum oxynitride 12705-37-2, Chromium nitride 12738-11-3, Nickel nitride 39301-25-2, Boron oxynitride 51845-89-7, Germanium nitride RL: DEV (Device component use); USES (Uses) (barrier; environmental barrier materials for encapsulated organic light-emitting devices) 71812-36-7, PET 25038-76-0 IT RL: DEV (Device component use); PRP (Properties); USES (Uses) (barrier; environmental barrier materials for encapsulated organic light-emitting devices) 115-11-7, Isobutylene, uses 4026-23-7, IT78-79-5, Isoprene, uses Benzocyclobutadiene 9010-77-9, Ethylene-acrylic acid copolymer 24937-78-8, Ethylene vinyl acetate copolymer 25038-76-0D, Polynorbornene, compds. 25722-33-2, Parylene RL: DEV (Device component use); USES (Uses) (decoupling layers; environmental barrier materials for encapsulated organic light-emitting devices) 12039-88-2, Tungsten disilicide 12033-62-4, Tantalum nitride IT 12045-63-5, Titanium diboride 12045-64-6, Zirconium diboride 25583-20-4, Titanium nitride 25658-42-8, 12648-34-9, Niobium nitride Zirconium nitride 25817-87-2, Hafnium nitride RL: DEV (Device component use); USES (Uses) (opaque cermet barrier; environmental barrier materials for encapsulated organic light-emitting devices) 9003-29-6, Polybutylene IT

RL: DEV (Device component use); USES (Uses) (polybutylenes decoupling layers; environmental barrier materials for encapsulated organic light-emitting devices)

7440-21-3, Silicon, uses ΙT

> RL: DEV (Device component use); USES (Uses) (substrate; environmental barrier materials for encapsulated organic light-emitting devices)

> > Page 9

- L33 ANSWER 5 OF 17 HCA COPYRIGHT 2004 ACS on STN
- 136:190811 State of the art: luminescent films prepared by sol-gel process. Lin, Jun; Yu, Min; Pang, Mao-lin; Zhou, Yong-hui; Han, Xiu-mei; Zhang, Hong-jie (Changchun institute of Applied Chemistry, Chinese Academy of Sciences, Changchun, 130022, Peop. Rep. China). Faguang Xuebao, 22(4), 373-383 (English) 2001. CODEN: FAXUEW. ISSN: 1000-7032. Publisher: Kexue Chubanshe.
- AB A review. The basic processes, characterization methods, and current development and application situation for luminescent films fabricated by sol-gel method are considered. Classified by compns., the sol-gel derived luminescent films include inorg. luminescent films and organic/inorg. hybrid luminescent films
 - , whose photoluminescent, cathodoluminescent, electroluminescent and field emission properties have been widely studied. Besides the silicate phosphor films which mainly employed alkoxysilanes as the main precursors for sol-gel transition, the authors also prepared other important phosphor films such as vanadates doped with rare earth ions by Pechini sol-gel process using inorg. salts as precursors, and realized the patterning of the phosphor films by soft lithog. (micro-molding in capillaries). Finally, the future development tendency for the luminescent films are forecasted.
- CC 73-0 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 Section cross-reference(s): 74
- L33 ANSWER 6 OF 17 HCA COPYRIGHT 2004 ACS on STN
- 136:141682 Organic-inorganic hybrid thin films as new optical materials.

 Matsukawa, Kimihiro; Matsuura, Yukihito; Inoue, Hiroshi; Naito, Hiroyoshi;
 Kanemitsu, Yoshihiko (Osaka Municipal Tech. Res. Inst., Japan). Kotai
 Butsuri, 37(1), 19-25 (Japanese) 2002. CODEN: KOTBA2. ISSN:
 0454-4544. Publisher: Agune Gijutsu Senta.
- AB A review. The polysilane-silica hybrid thin films were prepared by sol-gel method using polysilane copolymers, and their optical properties have been studied. In addition to well-known properties of polysilanes, these hybrid thin films exhibited properties such as photoluminescence (PL), photo-degradation, refractive index change, PL linear polarization memory, and time-resolved photoluminescence. These hybrid thin films are unique optical materials and seemed the most likely candidate for a opto-electronic devices.
- CC 73-0 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 Section cross-reference(s): 38
- IT Luminescence

(time-resolved; organic-inorg. hybrid thin films as new optical materials in relation to)

- L33 ANSWER 7 OF 17 HCA COPYRIGHT 2004 ACS on STN
- 135:20237 Synthesis and luminescence properties of organic-inorganic hybrid thin films doped with Eu(III). Li, Y. H.; Zhang, H. J.; Wang, S. B.; Meng, Q. G.; Li, H. R.; Chuai, X. H. (Key Laboratory of Rare Earth Chemistry and Physics, Changchun Institute of Applied Chemistry, Chinese Academy of Sciences, Changchun, 130022, Peop. Rep. China). Thin Solid Films, 385(1,2), 205-208 (English) 2001. CODEN: THSFAP. ISSN: 0040-6090. Publisher: Elsevier Science S.A..
- AB Silica-based transparent organic-inorg. hybrid films were prepared by the sol-gel method. Tetraethoxysilane and 3-(trimethoxysilyl)propyl methacrylate were used as the inorg. and organic compds., resp. Lanthanide

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complexes [Eu(phen)2]Cl3 were incorporated into the organically modified
     silicates and the luminescence properties of the resultant hybrid films
     were characterized. The relative quantum efficiency was observed higher and
     the lifetimes were longer in hybrid films than those in pure silica films.
     Furthermore, thermal stability of hybrid films incorporating various
     concentration of Eu(III) complex was studied.
     37-3 (Plastics Manufacture and Processing)
CC
     Section cross-reference(s): 38, 73
IT
     Silsesquioxanes
     RL: POF (Polymer in formulation); PRP (Properties); SPN (Synthetic
     preparation); PREP (Preparation); USES (Uses)
        (acrylic-silicate-; synthesis and luminescence properties of
        organic-inorg. hybrid thin films doped with
        Eu(III))
IT
     Hybrid organic-inorganic materials
        (doped with lanthanide complexes; synthesis and luminescence
        properties of organic-inorg. hybrid thin films
        doped with Eu(III))
IT
     Sol-gel processing
        (polymerization; synthesis and luminescence properties of
        organic-inorg. hybrid thin films doped with
        Eu(III))
IT
     Polymerization
        (sol-gel; synthesis and luminescence properties of
        organic-inorg. hybrid thin films doped with
ΙT
     Dopants
     Luminescence
     Thermal stability
        (synthesis and luminescence properties of org
        .-inorg. hybrid thin films doped with Eu(III))
IT
     22763-33-3
     RL: MOA (Modifier or additive use); USES (Uses)
        (dopant; synthesis and luminescence properties of org
        .-inorg. hybrid thin films doped with Eu(III))
ΙT
     7631-86-9, Silica, uses
     RL: NUU (Other use, unclassified); USES (Uses)
        (substrate; synthesis and luminescence properties of
        organic-inorg. hybrid thin films doped with
        Eu(III))
IT
     141087-50-5P
     RL: POF (Polymer in formulation); PRP (Properties); SPN (Synthetic
     preparation); PREP (Preparation); USES (Uses)
        (synthesis and luminescence properties of org
        .-inorg. hybrid thin films doped with Eu(III))
L33 ANSWER 8 OF 17 HCA COPYRIGHT 2004 ACS on STN
134:333315 Progress in luminescent films prepared by sol-gel process. Lin,
     Jun; Pang, Mao-Lin; Han, Yin-Hua; Zhou, Yong-Hui; Yu, Min; Zhang, Hong-Jie
     (Laboratory of Rare Earth Chemistry and Physics, Changchun Institute of
     Applied; Chemistry, Chines, Changchun, 130022, Peop. Rep. China). Wuji
     Huaxue Xuebao, 17(2), 153-160 (Chinese) 2001. CODEN: WHUXEO.
     ISSN: 1001-4861. Publisher: Wuji Huaxue Xuebao Bianjibu.
     In this paper, state of the art for luminescent films prepared by sol-gel
AB
     process has been reviewed. The basic process and characteristics for the
     synthesis of luminescent films via sol-gel method, characterization
     methods for the films and the current status for the development and
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application of luminescent films are discussed in the context. An

elucidation has been made on the luminescent films classified by composition, including inorg. luminescent films and organic/inorg.

hybrid luminescent films. The sol-gel derived luminescent films have-found applications in the display devices for photoluminescence, electroluminescence, cathodoluminescence and field emission etc. The future development tendency for the luminescent films are forecasted. A review with 40 refs.

- CC 73-0 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 Section cross-reference(s): 74
- L33 ANSWER 9 OF 17 HCA COPYRIGHT 2004 ACS on STN 133:315364 Two-layer light emitting diodes prepare
- 133:315364 Two-layer light emitting diodes prepared by the sol-gel route. De Morais, Tony Dantas; Chaput, Frederic; Boilot, Jean-Pierre; Lahlil, Khalid; Darracq, Bruno; Levy, Yves (Groupe de chimie du solide, Laboratoire de physique de la matiere condensee, UMR CNRS 7643, Ecole polytechnique, Palaiseau, 91128, Fr.). Comptes Rendus de l'Academie des Sciences, Serie IV: Physique, Astrophysique, 1(4), 479-491 (English) 2000. CODEN: CRACFI. Publisher: Editions Scientifiques et Medicales Elsevier.
- AB Green-emitting organic-inorg. hybrid light-emitting diodes (HLED) were formed of two hybrid thin layers, exhibiting different functionalities, which are sandwiched between indium-tin oxide (ITO) and metallic electrodes. The layers were prepared from silane precursors modified with hole transporting units and light-emitting naphthalimide moieties by the sol-gel technique. The hole transporting sol-gel layers exhibit about the same charge mobility as organic polymers having equivalent active units. The maximum external quantum efficiency of the best diode using LiF/Al cathode was about 1% and the luminance reaches 4000 cd·m-2.
- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related
 Properties)
 Section cross-reference(s): 76
- ST sol gel processing light emitting device
- IT Electroluminescent devices
 Semiconductor device fabrication
 Sol-gel processing
 (two-layer light-emitting diode

(two-layer light-emitting diodes prepared by sol-gel route)

- IT 301651-54-7P 301651-56-9P 301651-58-1P 301651-60-5P
 RL: PRP (Properties); RCT (Reactant); SPN (Synthetic preparation); PREP
 (Preparation); RACT (Reactant or reagent)
 (two-layer light-emitting diodes prepared by sol-gel
 route)
- L33 ANSWER 10 OF 17 HCA COPYRIGHT 2004 ACS on STN
- 133:10725 Optical properties of (organic polysilane)-(inorganic matrix) hybrid thin films. Mimura, S.; Naito, H.; Kanemitsu, Y.; Matsukawa, K.; Inoue,

- H. (Department of Physics and Electronics, Osaka Prefecture University, Sakai, Osaka, Japan). Journal of Luminescence, 87-89, 715-717 (English) 2000. CODEN: JLUMA8. ISSN: 0022-2313. Publisher: Elsevier Science B.V..
- AB Polysilane-inorg, hybrid thin films organic polysilane embedded in a SiO2 matrix were fabricated using a sol-gel method to improve the durability of organic polysilanes as optoelec, devices. Photoluminescence measurements at 10 K show that the durability against UV light exposure is improved in the polysilane-inorg, hybrid thin films. The luminescence linear polarization memory is found at 10 K, suggesting the decrease in the interchain interaction of polysilanes in the polysilane-inorg, hybrid thin films.
- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related
 Properties)
 Section cross-reference(s): 36
- silane polymer org hybrid inorg film optical property; LED silane polymer org hybrid inorg film UV durability; luminescence silane polymer org hybrid inorg film; UV spectra silane polymer org hybrid inorg film; sol gel silane polymer org inorg film optical property; exciton confinement silane polymer org inorg film optical property; optoelec device silane polymer org inorg film optical property; polarization luminescence silane polymer org inorg film sol gel; memory polarization luminescence silane polymer org inorg film
- L33 ANSWER 11 OF 17 HCA COPYRIGHT 2004 ACS on STN
 131:357893 Organic light emitting micro-pixels based on
 hybrid sol-gel glass arrays. Rantala, J. T.; Jabbour, G. E.; Vahakangas,
 J.; Honkanen, S.; Kippelen, B.; Peyghambarian, N. (Optical Sciences
 Center, The University of Arizona, Tucson, AZ, 85721, USA). Advances in
 Science and Technology (Faenza, Italy), 27(Innovative Light Emitting
 Materials), 283-290 (English) 1999. CODEN: ASETE5. Publisher:
 Techna.
- AB We demonstrate a novel technique of fabricating organic lightemitting devices. Each device consists of 1480 micro-pixels, with a pixel dimension of 45 + 45 $\mu m2$. The pixels were obtained by using a single-step UV patternable sol-gel hybrid glass thin film. More than 1% in external quantum efficiency and green light exceeding 27,000 cd/m2 are demonstrated.
- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 Section cross-reference(s): 57, 74
- ST sol gel glass pattern org light emitting device
- IT Photolithography

(UV; patterned hybrid sol-gel glass array on ITO for organic light emitting devices)

IT Electroluminescent devices

(high-resolution organic light emitting devices using UV-patterned hybrid sol-qel glass on ITO electrode)

IT Ceramers

Electric current-potential relationship

Optical imaging devices

Sol-gel processing

(organic light emitting devices using UV-patterned hybrid sol-gel glass)

IT 50926-11-9, **ITO**

RL: DEV (Device component use); USES (Uses)

(anode; UV-patterned hybrid sol-gel glass array on

ITO for organic light emitting devices)

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7439-95-4, Magnesium, uses
     RL: DEV (Device component use); USES (Uses)
        (cathode; organic light emitting devices using
        UV-patterned hybrid sol-gel glass)
ΙT
     2085-33-8, Tris(8-quinolinolato)aluminum
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PRP (Properties); PROC (Process); USES (Uses)
        (emissive layer; organic light emitting devices using
        UV-patterned hybrid sol-gel glass)
ΙT
     65181-78-4, TPD
     RL: DEV (Device component use); USES (Uses)
        (hole transport; organic light emitting devices using
        UV-patterned hybrid sol-gel glass)
ΙT
     947-19-3, 1-Hydroxycyclohexyl phenyl ketone
     RL: NUU (Other use, unclassified); USES (Uses)
        (photoinitiator; sol-gel patterned glass for organic light
        emitting devices)
IT
     79-41-4, Methacrylic acid, reactions 2530-85-0
                                                        23519-77-9,
     Zirconium(4+) propoxide
     RL: RCT (Reactant); RACT (Reactant or reagent)
        (sol-gel patterned glass for organic light emitting
        devices)
L33 ANSWER 12 OF 17 HCA COPYRIGHT 2004 ACS on STN
130:344496 Orange and green electroluminescence with hybrid
     light-emitting diodes. De Morais, Tony Dantas; Chaput,
     Frederic; Lahlil, Khalid; Boilot, Jean-Pierre (Groupe de Chimie du Solide,
     Laboratoire de Physique de la Matiere Condensee, UMR CNRS 7643, Ecole
     Polytechnique, Palaiseau, 91128, Fr.). Proceedings of SPIE-The
     International Society for Optical Engineering, 3476(Organic Light-Emitting
     Materials and Devices II), 338-348 (English) 1998. CODEN:
     PSISDG. ISSN: 0277-786X. Publisher: SPIE-The International Society for
     Optical Engineering.
AB
    The authors have elaborated for the 1st time organic-inorg. hybrid
     light-emitting diodes (HLED). These devices emitting in
     the orange and in the green are formed of one, two or three hybrid
     thin layers exhibiting different functionalities and sandwiched
     between In-Sn oxide (ITO) and metallic electrodes.
     These layers were prepared by the sol-gel technique from silane precursors
    modified with hole or electron transporting units and with light
     -emitting DCM or naphthalimide moieties.
CC
    73-5 (Optical, Electron, and Mass Spectroscopy and Other Related:
     Properties)
     Section cross-reference(s): 29, 36, 72
    electroluminescence hybrid light emitting
    diode multilayer device
    Luminescence
    Luminescence, electroluminescence
     Organic synthesis
    Oxidation potential
     Reduction potential
     Sol-gel processing
        (orange and green electroluminescence with hybrid
       light-emitting diodes)
TΤ
    Electroluminescent devices
        (organic-inorg. hybrid; orange and green electroluminescence)
     147-14-8, Copper phthalocyanine 7429-90-5, Aluminum, uses 7440-57-5,
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Gold, uses

7440-70-2, Calcium, uses

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RL: DEV (Device component use); USES (Uses)
        (electrode materials for green light emitting
ΙT
     78-10-4, Tetraethoxysilane 2031-67-6
                                              9011-14-7, PMMA 15082-28-7
     25067-59-8, 9H-Carbazole, 9-ethenyl-, homopolymer
     RL: DEV (Device component use); PRP (Properties); RCT (Reactant); RACT
     (Reactant or reagent); USES (Uses)
        (orange and green electroluminescence with hybrid
        light-emitting diodes)
ΙT
     219535-34-9P 221105-38-0P
                                   224563-85-3P 224563-91-1P
     RL: DEV (Device component use); PRP (Properties); SPN (Synthetic
     preparation); PREP (Preparation); USES (Uses)
        (orange and green electroluminescence with hybrid
        light-emitting diodes)
IT
     119438-04-9
                 224563-94-4
     RL: PRP (Properties); RCT (Reactant); RACT (Reactant or reagent)
        (orange and green electroluminescence with hybrid
        light-emitting diodes)
TI
     194354-31-9P
     RL: PRP (Properties); RCT (Reactant); SPN (Synthetic preparation); PREP
     (Preparation); RACT (Reactant or reagent)
        (orange and green electroluminescence with hybrid
        light-emitting diodes)
L33 ANSWER 13 OF 17 HCA COPYRIGHT 2004 ACS on STN
130:229731 Hybrid organic-inorganic light-emitting diodes.
     Dantas de Morais, Tony; Chaput, Frederic; Lahlil, Khalid; Boilot,
     Jean-Pierre (Groupe Chimie Solide, Laboratoire Physique Matiere Condensee,
     Ecole Polytechnique, Palaiseau, F-91128, Fr.). Advanced Materials
     (Weinheim, Germany), 11(2), 107-112 (English) 1999. CODEN:
     ADVMEW. ISSN: 0935-9648. Publisher: Wiley-VCH Verlag GmbH.
AΒ
    To improve the aging and environmental stability of LEDs, hybrid
     organic-inorg. materials consisting of 2-3 layers with different
     functionalities were synthesized using the sol-gel technique. These
     layers were prepared from silane precursors with hole- or
     electron-transporting units and light-emitting
     species. For the emissive layers the authors used Si-DCM prepared by
     reacting the OH groups of 4-dicyanomethylene-2-Me-6-[p-
     (dimethylamino)styryl]-4H-pyran (DCM) and the isocyanate group
     3-(isocyanatopropyl)triethoxysilane in DMF. SiDCM was copolymd. with
    methyltriethoxysilane and doped by 2-(4-biphenylyl)-5-(4-tert-butylphenyl)-
     1,3,4-oxadiazole (PBD) or Si-PBD. As hole transport layer
    polyvinylcarbazole or 9-[3-(1,1,1-triethoxysilyl)propyl]-9H-carbazole +
    TEOS was used. The electroluminescent properties of the sol-gel
    materials were demonstrated by manufacturing devices which emitted in the
orange
     consisting of the organic-inorg. multilayer sandwiched between a transparent
     ITO electrode and an evaporated Al cathode.
    73-11 (Optical, Electron, and Mass Spectroscopy and Other Related
     Properties)
    Section cross-reference(s): 36, 38, 76
ST
    light emitting diode sol gel fabrication; LED org
    inorg multilayer electroluminescence efficiency;
     cyanomethylenepyranylvinylphenylaminoethyl ethoxysilylpropylcarbamate
    hybrid LED electroluminescence; biphenylylphenyl oxadiazole
    ethoxysilylpropylcarbamate hybrid LED electroluminescence;
     current voltage LED hybrid org inorg silane precursor
TΤ
    Sol-gel processing
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(coating; hybrid organic-inorg. LEDs fabricated by sol-gel process from silane-based precursors)

IT Electroluminescent devices

(current-voltage-, luminance-voltage characteristics, and luminescence and **electroluminescence** spectra of hybrid organic-inorg. LEDs fabricated by sol-gel process from silane-based precursors)

IT Electric current-potential relationship

Luminescence

(of hybrid **organic**-inorg. LEDs fabricated by sol-gel process from silane-based precursors)

IT Luminescence, electroluminescence

(spectra; of hybrid organic-inorg. LEDs fabricated by sol-gel process from silane-based precursors)

IT 221105-35-7

RL: DEV (Device component use); MOA (Modifier or additive use); PRP (Properties); USES (Uses)

(dopant; current-voltage-, luminance-voltage characteristics, and luminescence and **electroluminescence** spectra of hybrid organic-inorg. LEDs fabricated by sol-gel process from silane-based precursors)

IT 25067-59-8, Polyvinylcarbazole

RL: DEV (Device component use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)

(hole transport layer; hybrid organic-inorg. LED sol-gel fabrication and characterization by current-voltage, luminance-voltage, luminescence, and electroluminescence using)

L33 ANSWER 14 OF 17 HCA COPYRIGHT 2004 ACS on STN

- 130:189087 Organic/inorganic hybrid electroluminescent devices prepared via sol-gel process. Keum, Ji Hwan; Kang, Eunjung; Kim, Youngkyoo; Cho, Won Jei; Ha, Chang Sik (Department of Polymer Science and Engineering, Pusan National University, Pusan, 609-735, S. Korea). Molecular Crystals and Liquid Crystals Science and Technology, Section A: Molecular Crystals and Liquid Crystals, 316, 297-300 (English) 1998. CODEN: MCLCE9. ISSN: 1058-725X. Publisher: Gordon & Breach Science Publishers.
- Organic/inorg. hybrid thin film was introduced into organic electroluminescent device (ELD) to enhance the device stability. The inorg. network structure was prepared via sol-gel reaction from tetraethoxysilane (TEOS) in the presence of H2O. 4-(Dicyanomethylene)-2-Me-6-(4-dimethylaminostyryl)-4H-pyran(DCM) was used as an organic lumophore. The ELD was fabricated in a simple structure of anode/hybrid layer/cathode. The turn-on voltage of the ELD was .apprx.30 Vdc with the strong emission at 40 Vdc. The color of the emitted light was light green, meaning a blue shift from the color of the resp. solution
- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)

Section cross-reference(s): 57, 76

IT Sol-gel processing

(coating; organic/inorg. hybrid

electroluminescent devices prepared via sol-gel process)

IT Electroluminescent devices

(thin-film; organic/inorg. hybrid

electroluminescent devices prepared via sol-gel process)

L33 ANSWER 15 OF 17 HCA COPYRIGHT 2004 ACS on STN

127:25373 Hybrid film electroluminescent a.c.

emitter. Gurin, N. T.; Sabitov, O. Yu. (Mosk. Gos. Univ., Ulyanovsk,

432700, Russia). Zhurnal Tekhnicheskoi Fiziki, 66(11), 201-202 (Russian) 1996. CODEN: ZTEFA3. ISSN: 0044-4642. Publisher: Nauka.

- AB The electroluminescent devices with the thick dielec. layer deposited on the thin-layered structure were fabricated. The metal-dielec.-semiconductor-dielec.-metal and metal-dielec.-semiconductor-dielec.-thick dielec.-metal structures were examined The brightness-voltage characteristics were analyzed in a function of annealing conditions.
- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
- ST hybrid film electroluminescent electroluminescence emitter; zinc sulfide zirconium yttrium oxide emitter
- IT Electroluminescent devices
 Luminescence, electroluminescence
 (hybrid film electroluminescent a.c.
 emitter)
- IT Annealing

(optimization; hybrid film

electroluminescent a.c. emitter)

IT 1314-98-3, Zinc sulfide, uses 7429-90-5, Aluminum, uses 18282-10-5, Tin dioxide 119513-25-6, Yttrium zirconium oxide y0.26zr0.87o2.13 RL: DEV (Device component use); USES (Uses)

(hybrid film electroluminescent a.c.
emitter)

TT 7439-96-5, Manganese, uses
RL: DEV (Device component use); MOA (Modifier or additive use); USES
(Uses)

(hybrid film electroluminescent a.c.
emitter)

- L33 ANSWER 16 OF 17 HCA COPYRIGHT 2004 ACS on STN
- 120:91115 Hybrid silicon molecular beam epitaxial regrowth for a strained silicon-germanium/silicon single-quantum-well electroluminescent device. Kato, Y.; Fukatsu, S.; Usami, N.; Shiraki, Y. (Tokyo Res. Lab., IBM, Yamato, 242, Japan). Applied Physics Letters, 63(17), 2414-16 (English) 1993. CODEN: APPLAB. ISSN: 0003-6951.
- An n-type Si contact layer for an electroluminescent (EL) diode was successfully grown on a Si/Sil-xGex/Si single-quantum-well (SQW) structure by hybrid Si MBE for the 1st time. The hybrid MBE was performed by regrowing the Si contact layer in a solid-source MBE chamber after transferring the SQW sample through air from a gas-source (GS) MBE chamber, in which the starting SQW structure was grown. A (2 + 1) reconstruction was observed on a GSMBE-prepared Si(100) surface even after the SQW sample was exposed to air for up to 15 h. An excellent quality of the EL device was evidenced by the sharpest emission lines ever reported in the EL spectra of SiGe system. The spectral features of the EL and photoluminescence are almost identical, and a well-resolved acoustic phonon replica was observed
- CC 75-1 (Crystallography and Liquid Crystals)
 Section cross-reference(s): 73
- IT Epitaxy

(mol.-beam, of silicon hybrid layer, for electroluminescent diode)

- L33 ANSWER 17 OF 17 HCA COPYRIGHT 2004 ACS on STN
- 119:106015 Hybrid thin film-powder

electroluminescent device. Aoki, Yuichi; Enjoji, Katsuhisa; Yoshii, Tetsuo; Anzaki, Toshiaki; Wada, Shunji (Nippon Sheet Glass Co.,

- Ltd., Japan). Jpn. Kokai Tokkyo Koho JP 04363895 A2 19921216 Heisei, 7 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 1991-286049 19911031. PRIORITY: JP 1991-13837 19910111.
- AB The title device, suited for use as a character and graphic display, consisting of a transparent **electrode**, a luminescent layer, a current-limiting layer of compacted conductive fine powder, and a back side **electrode**, formed in that order on a transparent insulator base, further comprises an electron barrier layer disposed between the transparent **electrode** and the luminescent layer and/or between the luminescent layer and the current-limiting layer.
- IC ICM H05B033-22 ICS G09F009-30
- CC 74-13 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes) Section cross-reference(s): 73
- ST **hybrid** thin **film** powder **electroluminescent** display
- => d L34 1-22 cbib abs hitind hitrn
- L34 ANSWER 1 OF 22 HCA COPYRIGHT 2004 ACS on STN

 137:348760 Sheet apparatus of composite material for detecting complementary nucleic acid fragments from the living body. Hosoi, Yuichi (Fuji Photo Film Co., Ltd., Japan). Eur. Pat. Appl. EP 1258287 A2 20021120, 10 pp. DESIGNATED STATES: R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR. (English). CODEN: EPXXDW. APPLICATION: EP 2002-11216 20020521. PRIORITY: JP 2001-150018 20010518.
- AB The invention concerns a composite material sheet favorably utilizable for anal. of substances originating from living body or its analogs has partitions two-dimensionally extending on a sheet plane to form fine sections surrounded by the partitions and porous material. Further, portions each of which is placed in the fine section, in which the partitions are made of material having a mean d. of 0.6g/cm or higher and the porous material portions have a mean d. of 1.0g/cm or lower, under the condition that the mean d. of material of the partitions is higher than the mean d. of the material of the porous material portions. Diagrams describing the apparatus assembly and operation are given.
- IC ICM B01J019-00 ICS C12Q001-68
- CC 9-1 (Biochemical Methods)
 Section cross-reference(s): 3
- IT Apparatus Ceramics

Immobilization, molecular or cellular

Light sources

Nucleic acid hybridization

Phosphors

(sheet apparatus of composite material for detecting complementary nucleic acid fragments from the living body)

- L34 ANSWER 2 OF 22 HCA COPYRIGHT 2004 ACS on STN
- 137:301920 Semiconductor light-emitting device and method for manufacturing the same. Wang, Tien Yang (USA). U.S. US 6469324 B1 20021022, 20 pp. (English). CODEN: USXXAM. APPLICATION: US 2000-577446 20000524. PRIORITY: US 1999-PV135946 19990525.
- AB Semiconductor (e.g., AlGaInP) light-emitting devices

are described which comprise a substrate on a first electrode; an active layer bounded by an upper and a lower confining layer overlaying the substrate; a window layer overlaying the upper confining layer; a contact layer overlaying the window layer; a second electrode on the contact layer; a first metal layer overlaying the entire surface of the contact layer between the contact layer and the second electrode; a first transparent conductive oxide layer between the first metal layer and the second electrode, and overlaying the entire surface of the first metal layer; a second metal (e.g., Ag) layer between the substrate and the lower confining layer; and a second transparent conductive oxide (e.g., of In Sn oxide) layer between the second metal layer and the lower confining layer. The second metal and second oxide layers form a hybrid reflective structure at the substrate interface that results in reduced substrate absorption loss and light piping; the upper metal and oxide layers serve as a hybrid antirfelective structure promoting light extraction

IC ICM H01L033-00

NCL 257098000

- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related
 Properties)
 Section cross-reference(s): 76
- ST electroluminescent device conductive reflector hybrid antireflection layer
- IT Electroluminescent devices

(light-emitting devices with lower hybrid

reflective structures and upper hybrid antireflective structures)

TT 7440-22-4, Silver, uses 50926-11-9, Indium tin oxide 163207-18-9 Aluminum gallium indium phosphide

RL: DEV (Device component use); USES (Uses)

(light-emitting devices with lower hybrid

reflective structures and upper hybrid antireflective structures)

- L34 ANSWER 3 OF 22 HCA COPYRIGHT 2004 ACS on STN
- 137:224258 Organic-inorganic hybrid films with good oxygen and water vapor barrier properties for organic electroluminescent

(EL) elements and organic EL devices therewith.
Sawai, Yuichi; Oishi, Tomoji; Kaneko, Yoshiyuki; Aratani, Sukekazu

(Hitachi Ltd., Japan). Jpn. Kokai Tokkyo Koho JP 2002260848 A2 20020913, 7 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 2001-60446 20010305.

- AB Title films contain fluoro groups, siloxane groups, and photosensitive groups. Thus, 1:1:1 mol mixture of trifluoroalkyltrimethoxysilane CF3(CH2)nSi(OCH3)3 (n = 1-10), alkoxy group-containing photosensitive acrylic resin, and trimethoxyvinylsilane was hydrolytically polycondensed to give an organic-inorg. hybrid solution, which was applied on a 12.1 μm-thick PET substrate and cured with UV to give a 13.2 μm-thick film with oxygen permeability 0.55 cc/m2/day and water vapor permeability 0.61 g/m2/day.
- IC ICM H05B033-04

ICS C08F299-08; H05B033-14

- CC 74-13 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes) Section cross-reference(s): 38, 42, 73
- ST org inorg hybrid film oxygen water vapor barrier electroluminescent; EL device fluoro methoxysilane polymer prepn
- IT Silsesquioxanes

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (acrylic; preparation of inorg.-organic hybrid films with

good oxygen and water vapor barrier properties for organic EL

devices)

IT Coating materials

> (impermeable; preparation of inorg.-organic hybrid films with good oxygen and water vapor barrier properties for EL devices

ITElectroluminescent devices

Electronic packaging materials

(preparation of inorg.-organic hybrid films with good oxygen and water vapor barrier properties for EL devices)

ITHybrid organic-inorganic materials

Laminated plastic films

(preparation of inorg.-organic hybrid films with good oxygen and water vapor barrier properties for organic EL devices)

ITPolyesters, uses

> RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(substrate; preparation of inorg.-organic hybrid films with good oxygen and water vapor barrier properties for organic EL devices)

IΤ 1305-78-8, Calcium oxide, uses 1309-48-4, Magnesium oxide, uses 1344-28-1, Aluminum oxide, uses 7631-86-9, Silicon dioxide, uses 11126-22-0, Silicon oxide 12033-89-5, Silicon nitride, uses RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(preparation of inorg.-organic hybrid films with good oxygen and water vapor barrier properties coated with or containing)

2487-90-3DP, Trimethoxysilane, trifluoroalkyl derivs., polymers with alkoxy-containing acrylic resins and trimethoxyvinylsilane 2768-02-7DP, Trimethoxyvinylsilane, polymers with trifluoroalkyltrimethoxysilane and alkoxy-containing acrylic resins

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (preparation of inorg.-organic hybrid films with good oxygen and water vapor barrier properties for organic EL devices)

25038-59-9, Polyethylene terephthalate, uses ΤТ RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(substrate; preparation of inorg.-organic hybrid films with good oxygen and water vapor barrier properties for organic EL devices)

L34 ANSWER 4 OF 22 HCA COPYRIGHT 2004 ACS on STN

137:101267 Thin film electroluminescent device having thin-film current control layer. Kim, Yong-shin; Yun, Sun Jin; Park, Sang-hee; Lee, Yong Eui (S. Korea). U.S. Pat. Appl. Publ. US 2002101153 A1 20020801, 10 pp. (English). CODEN: USXXCO. APPLICATION: US 2001-978456 20011016. PRIORITY: KR 2000-72323 20001201.

A thin-film electroluminescent device (ELD) is described comprising a stacking of a transparent substrate, transparent electrodes, a thin-film phosphor layer, a thin-film current control layer and metal electrodes, wherein the thin-film current control layer acts as an energy barrier layer, which supplies energetic electrons into the phosphor layer by a field-assistant injection of electron, and a current-limiting layer which prevents an elec. field breakdown of the electroluminescent device caused by an excess current flow. A thin-film electroluminescent device may comprise a stacking of a transparent

substrate, transparent electrodes, a thin-film phosphor layer, a thin-film energy barrier layer, a thin-film current-limiting layer and metal electrodes, wherein the energy barrier layer supplies energetic electrons into the phosphor layer by a field-assistant injection of electron, and the current-limiting layer prevents an elec. field breakdown of the electroluminescent device caused by an excess current flow. The ELD has the advantages of having a lower operation voltage than that of the conventional thin-film a.c. ELD and a higher resolution than that of the conventional thin-film/powder hybrid d.c. ELD. The thin-film current control layer acts as an energy barrier layer which supplies energetic electrons into the phosphor layer by a field-assistant injection of electron, and a current-limiting layer which prevents an elec. field breakdown of the electroluminescent device caused by an excess current flow.

- IC ICM H05B033-22
- NCL 313506000
- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related
 Properties)
 Section cross-reference(s): 76
- ST thin film electroluminescent device current control
- IT Electroluminescent devices

(thin-film; thin film electroluminescent device having thin-film current control layer)

- IT 1314-61-0, Tantalum oxide (Ta2O5) 1344-28-1, Alumina, uses 7631-86-9, Silica, uses 13463-67-7, Titanium oxide (TiO2), uses 132614-63-2, Silicon nitride oxide (SiNO)
 - RL: DEV (Device component use); USES (Uses)

(current control layer containing; thin film electroluminescent device having thin-film current control layer)

IT 1304-28-5, Barium oxide (BaO), uses 1304-39-8, Barium selenide (BaSe) 1305-84-6, Calcium selenide (CaSe) 1306-23-6, Cadmium sulfide (CdS), uses 1314-13-2, Zinc oxide (ZnO), uses 1314-96-1, Strontium sulfide (SrS) 1314-98-3, Zinc sulfide (ZnS), uses 1315-09-9, Zinc selenide (ZnSe) 12009-36-8, Barium telluride (BaTe) 12013-57-9, Calcium telluride (CaTe) 12040-08-3, Strontium telluride (SrTe) 20548-54-3, Calcium sulfide (CaS) 21109-95-5, Barium sulfide (BaS) RL: DEV (Device component use); USES (Uses)

(energy barrier layer containing; thin film electroluminescent device having thin-film current control layer)

IT 7439-92-1, Lead, uses

RL: DEV (Device component use); MOA (Modifier or additive use); USES (Uses)

(thin film electroluminescent device having thin-film current control layer)

- L34 ANSWER 5 OF 22 HCA COPYRIGHT 2004 ACS on STN
- 137:70388 Water-vapor-impermeable transparent substrate films for electronic devices and their manufacture. Yamada, Taketoshi; Kita, Hiroshi; Saito, Koichi; Okubo, Yasushi (Konica Co., Japan). Jpn. Kokai Tokkyo Koho JP 2002194228 A2 20020710, 9 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 2000-392502 20001225.
- The films, for LCD and organic LED, are manufactured by casting of compns. comprising organic polymers (e.g., cellulose esters) satisfying solubility 0-5 g/100-g water and 25-100 g/100-g Me2CO at 25° and (hydrolyzates of) reactive (tetravalent) metal compds. The compns. satisfy alkali metal content <5000 ppm. The films may contain RfSiX14-n (Rf = F-containing alkyl or aryl; X1 = hydrolyzable group; n = 1-3). The LCD or LED using the substrate films keep high luminance for long time.

- IC ICM C08L101-00
 - ICS C08J005-18; G09F009-30; H01L031-04; H05B033-02; H05B033-14
- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 Section cross-reference(s): 38, 74
- ST water vapor impermeable cellulose ester LED substrate; silicate silsesquioxane cellulose acetate propionate film; methylethoxysilane ethoxysilane copolymer cellulose acetate hybrid film; display liq crystal transparent film substrate
- IT **Electroluminescent** devices
 - (organic; manufacture of transparent substrate films with low water-vapor permeability for electronic apparatus)
- L34 ANSWER 6 OF 22 HCA COPYRIGHT 2004 ACS on STN
 135:324573 Energy transfer in (organic polysilane)-(silica matrix)

 hybrid thin films. Naito, H.; Mimura, S.; Kobayashi,
 A.; Matsuura, Y.; Matsukawa, K.; Inoue, H.; Nihonyanagi, S.; Kanemitsu, Y.
 (Department of Physics and Electronics, Osaka Prefecture University,
 Sakai, Osaka, 599-8531, Japan). Thin Solid Films, 393(1,2), 199-203
 (English) 2001. CODEN: THSFAP. ISSN: 0040-6090. Publisher:
 Elsevier Science S.A..
- AB Excitation energy transfer in polysilane-SiO2 hybrid films prepared by a sol-gel method were studied in terms of steady-state and time-resolved luminescence (PL) at 10 K with decreasing polysilane concentration in the hybrid films, the degree of the PL linear polarization memory is increased and the mean PL lifetime is gradually increased. These results can be interpreted in terms of the spatial confinement of excitation energy within polysilane chains in the hybrid films because of the increase in the interchain separation. The information obtained here provides insights for optimizing nanostructured materials for use in optoelectronic devices.
- CC 73-5 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 - Section cross-reference(s): 36, 66
- ST energy transfer org polysilane silica matrix hybrid film
- IT Energy transfer
 - (energy transfer in organic polysilane-silica matrix hybrid films)
- IT Luminescence
 - Sol-gel processing
 - (of organic polysilane-silica matrix hybrid
 films)
- L34 ANSWER 7 OF 22 HCA COPYRIGHT 2004 ACS on STN
- 135:160099 High throughput optical near-field aperture array for data storage. Minh, Phan Ngoc; Ono, Takahito; Tanaka, Shuji; Goto, Kenya; Esashi, Masayoshi (Faculty of Engineering, Tohoku University, Sendai, 980-8579, Japan). IEEE International Conference on Micro Electro Mechanical Systems, Technical Digest, 14th, Interlaken, Switzerland, Jan. 21-25, 2001, 309-312. Institute of Electrical and Electronics Engineers: New York, N. Y. (English) 2001. CODEN: 69BHXI.
- AB To create and use a strong light source with sub-wavelength size has opened up a new field, the near-field optics. One of the most attractive applications of the near-field optics is the next generation optical data storage. The optical memory with high d. and high data transfer rate is highly demanded to use an array of high throughput nano-scaled light sources for writing and reading bits on a medium. The authors propose a hybrid laser and aperture array for

optical near-field memory head, VCSEL/NSOM. A systematic study of the optical performance of the near-field light at the aperture of the Si micromachined tip array is presented. A primarily result of writing and reading bits on a phase change medium using the fabricated structure is demonstrated.

- CC 74-12 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes) Section cross-reference(s): 73
- TT 7429-90-5, Aluminum, reactions
 RL: DEV (Device component use); MOA (Modifier or additive use); PEP (Physical, engineering or chemical process); RCT (Reactant); PROC (Process); RACT (Reactant or reagent); USES (Uses)
 (thin film opaque layer of, in hybrid VCSEL/NSOM near-field optical memory head containing silicon diaphragm)
- L34 ANSWER 8 OF 22 HCA COPYRIGHT 2004 ACS on STN
 133:342970 Characterization of the BaTiO3/p-Si interface and applications.
 Evangelou, E. K.; Konofaos, N.; Craven, M. R.; Cranton, W. M.; Thomas, C.
 B. (Applied Physics Laboratory, Physics Department, University of
 Ioannina, Ioannina, 451 10, Greece). Applied Surface Science, 166(1-4),
 504-507 (English) 2000. CODEN: ASUSEE. ISSN: 0169-4332.
 Publisher: Elsevier Science B.V..
- AΒ Barium titanate (BaTiO3), because of its high dielec. constant (.vepsiln.r), has proven to be a very promising candidate for use as dielec. layer in ac thin film electroluminescent (ACTFEL) devices and for use in thin film hybrid and integrated circuits. In the present work, BaTiO3 films were deposited on p-Si (100) substrates by rf-magnetron sputtering at a base temperature of 200°C. The electronic properties of the BaTiO3/p-Si interface were examined by means of admittance spectroscopy on metal-insulator-semiconductor (MIS) devices fabricated by thermal evaporation of Al. The d. of interface states (Dit) was calculated by both the capacitive and the conductive response of the traps; values of the order of 1012 eV-1 cm-2 were obtained for the Dit and values of 10-5 s were calculated for the relevant time consts. of the traps. These values, together with the dielec. constant of the films ranging between 40 and 60, show that the deposited films were suitable for use as cladding insulators in ACTFEL devices.
- CC 76-3 (Electric Phenomena)
- ST barium titanate silicon interface; electroluminescent device barium titanate silicon
- IT Density of interface states
 Dielectric constant
 Electric insulators

Electroluminescent devices

Electronic properties
Integrated circuits
Interface
MIS devices
Magnetron sputtering
Trapping

(characterization of BaTiO3/p-Si interface and applications)

L34 ANSWER 9 OF 22 HCA COPYRIGHT 2004 ACS on STN

133:244859 Single-source thermal ablation method for deposition of organic-inorganic hybrid films suitable for luminescence. Chondroudis, Konstantinos; Mitzi, David Brian; Prikas,

Michael Tony (International Business Machines Corporation, USA). U.S. US

6117498 A 20000912, 11 pp. (English). CODEN: USXXAM.

APPLICATION: US 1998-192130 19981113.

AB Stable films of organic-inorg. hybrid materials (especially perovskites) are applied with selected stoichiometric ratio on a substrate by: (a) placing the substrate and an organic-inorg. hybrid having selected stoichiometry in a vacuum-furnace chamber; (b) rapid heating of the hybrid for total ablation, especially at <10-3 torr or under flowing N2 atmospheric; and (c) deposition

of the hybrid film having selected stoichiometric ratio on the substrate. The hybrid feed is typically a perovskite material (R-NH4)2MX4 having R as an organic component, M as divalent metal, and X as a halogen, especially as (C4H9NH3)2SnI4 (I) or similar perovskites having 2-dimensional layered structure. The perovskite feed in optional solvent can be placed on Ta strip, and elec. heated for rapid evaporation and ablative vapor deposition as a stable film on adjacent substrate. The resulting I film shows optical luminescence spectrum with a sharp peak corresponding to radiative decay of excitons, showing the high film quality without thermal-dissociation damage in the deposition. The similar process is suitable for deposition of the hybrid films from non-perovskite organometal precursor, typically as NH3(CH2)6NH3BiI5 having a chain structure. The hybrid film is considered for electroluminescence applications.

IC ICM C23C008-54

NCL 427590000

CC 73-5 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
Section cross-reference(s): 29

IT 213555-69-2

RL: TEM (Technical or engineered material use); USES (Uses) (films, hot deposition of; hybrid films deposited on substrate by heating for single-source thermal ablation)

L34 ANSWER 10 OF 22 HCA COPYRIGHT 2004 ACS on STN
133:219043 Identification of a Novel β-Catenin-Interacting Protein.
 Kawajiri, Aie; Itoh, Naohiro; Fukata, Masaki; Nakagawa, Masato; Yamaga, Masaki; Iwamatsu, Akihiro; Kaibuchi, Kozo (Division of Signal Transduction, Nara Institute of Science and Technology, Ikoma, 630-0101, Japan). Biochemical and Biophysical Research Communications, 273(2), 712-717 (English) 2000. CODEN: BBRCA9. ISSN: 0006-291X. Publisher: Academic Press.

Cadherin is a well-known cell-cell adhesion mol., and it binds to AΒ β -catenin, which in turn binds to α -catenin. However, little is known about the regulatory mechanism underlying the cadherin-mediated cell-cell adhesion. Here we purified two novel β -catenin-interacting proteins with mol. masses of 180 kDa (p180) and 150 kDa (p150) from bovine brain cytosol by using glutathione S-transferase (GST)- β -catenin affinity column chromatog. Mass spectral anal. revealed p180 to be identical to KIAA0313 which has a putative Rapl quanine nucleotide exchange factor (GEF) domain and p150 to be the same as KIAA0705 which has a high degree of sequence similarity to the synaptic scaffolding mol. (S-SCAM), which binds β -catenin and KIAA0313 in the yeast twohybrid system and overlay assay, resp. β -Catenin was co-immunopptd. with KIAA0313 in Madin-Darby canine kidney II (MDCKII) cells, bovine brain cytosol, and EL cells. KIAA0313 and eta-catenin were partly co-localized at sites of cell-cell contact in MDCKII cells. Taken together, our data suggest that KIAA0313 assocs. with β -catenin through KIAA0705 in vivo at sites of cell-cell contact. (c) 2000 Academic Press.

CC 6-3 (General Biochemistry)

L34 ANSWER 11 OF 22 HCA COPYRIGHT 2004 ACS on STN

132:251964 Electroluminescent polymers. Elschner, A.; Bruder, F.;
Heuer, H.-W.; Karbach, A.; Thurm, S.; Wehrmann, R.; Andries, H.; Mortsel,
B.; Huppauff, M.; Mayer, A.; Jonda, Ch.; Brutting, W.; Schwoerer, M.
(Bayer AG, Krefeld, Germany). Werkstoffwoche '98, Band VIII: Symposium
10, Polymere; Symposium 14, Simulation Polymere, Munich, Sept., 1998,
Meeting Date 1998, 203-208. Editor(s): Michaeli, Walter. Wiley-VCH
Verlag GmbH: Weinheim, Germany. (German) 1999. CODEN: 68SRAZ.

A review without refs. describing results of the authors' own research projects. To realize extensive, efficient, long-life, and flexible organic light-emitting diodes (LEDs), several systems of low-mol. and polymeric compds. were evaluated with respect to electroluminescent properties, capability of continuous film coating, structuring of electrodes, and encapsulation of the organic devices. Using the poly(3,4-ethylenedioxythiophene)/poly(styrene sulfonate) system as conductive organic layer and dendritic phenylamines as photoluminescent component, a hybrid multilayer organic LED was constructed, optimized, and characterized. General conclusions based on these results are reported of.

CC 38-0 (Plastics Fabrication and Uses)

ST electroluminescent polymer optimization LED review

IT Polymers, uses

RL: DEV (Device component use); PRP (Properties); USES (Uses)

(electroluminescent; optimization of

electroluminescent polymer systems for use in LEDs)

IT Electroluminescent devices

(optimization of **electroluminescent** polymer systems for use in LEDs)

L34 ANSWER 12 OF 22 HCA COPYRIGHT 2004 ACS on STN 130:58888 Conductive layer system and use thereof in

electroluminescent systems. Huppauff, Martin; Sybrichs, Ralf; Gehrig, Andreas (Robert Bosch Gmbh, Germany). PCT Int. Appl. WO 9854767 Al 19981203, 21 pp. DESIGNATED STATES: W: JP, US; RW: AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE. (German) CODEN: PIXXD2. APPLICATION: WO 1998-DE1467 19980529. PRIORITY: DE 1997-19722946 19970531; DE 1997-19757874 19971224.

AB Transparent or semitransparent conductive layer systems consisting of organic and inorg. elec. conductive materials are described which comprise ≥2 layers, the first layer containing an organic or organometallic elec. conductive polymer which is transparent or semitransparent in the visible range of the electromagnetic spectrum while the second contains at least one elec. conductive inorg. compound or a metal or a metalloid doped accordingly. The layer systems forms a multilayer

hybrid electrode for use as a cathode in
electroluminescent systems. Use in displays is indicated.

IC ICM H01L051-20 ICS H05B033-28

CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
Section cross-reference(s): 76

ST org inorg layer cathode electroluminescent device

IT Cathodes

Electric contacts

Electroluminescent devices

Optical imaging devices

(elec. conductive multilayered systems including organic and inorg. layers

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and their use in electroluminescent systems)
TΤ
      Polyacetylenes, uses
      Polyanilines
      RL: DEV (Device component use); USES (Uses)
         (elec. conductive multilayered systems including organic and inorg. layers
         and their use in electroluminescent systems)
ΙT
      Polymers, uses
      RL: DEV (Device component use); USES (Uses)
         (polythiophenes; elec. conductive multilayered systems including organic
         and inorg. layers and their use in electroluminescent
         systems)
     Aluminum alloy
IT
     Chromium alloy
     Copper alloy
     Gold alloy
     Iron alloy
     Palladium alloy
     Platinum alloy
     Silver alloy
     Tin alloy
     RL: DEV (Device component use); USES (Uses)
         (elec. conductive multilayered systems including organic and inorg. layers
        and their use in electroluminescent systems)
     7429-90-5, Aluminum, uses 7439-89-6, Iron, uses 7440-05-3, Palladium,
IT
     uses 7440-06-4, Platinum, uses 7440-22-4, Silver, uses 7440-31-5,
     Tin, uses 7440-44-0, Carbon, uses 7440-47-3, Chromium, uses 7440-50-8, Copper, uses 7440-57-5, Gold, uses 11099-20-0 25233-30-1,
     Polyaniline
                   25233-34-5, Polythiophene 30604-81-0, Polypyrrole
     30604-81-0D, Polypyrrole, derivs. 50926-11-9, Indium tin oxide
     126213-51-2, 3,4-Polyethylenedioxythiophene
     RL: DEV (Device component use); USES (Uses)
        (elec. conductive multilayered systems including organic and inorg. layers
        and their use in electroluminescent systems)
IT
     1314-98-3, Zinc sulfide, uses
     RL: DEV (Device component use); USES (Uses)
        (electroluminescent elements based on; elec. conductive
        multilayered systems including organic and inorg. layers and their use in
        electroluminescent systems)
L34 ANSWER 13 OF 22 HCA COPYRIGHT 2004 ACS on STN
129:348680 Hybrid sol-gel micro-patterning of organic
     electroluminescent devices. Rantala, Juha T.; Jabbour, Ghassan
     E.; Vahakangas, Jouko; Honkanen, Seppo; Kippelen, Bernard; Peyghambarian,
     Nasser (Optical Sciences Center, University of Arizona, Tucson, AZ, 85721,
     USA). Japanese Journal of Applied Physics, Part 2: Letters, 37(10A),
     L1098-L1100 (English) 1998. CODEN: JAPLD8. ISSN: 0021-4922.
     Publisher: Japanese Journal of Applied Physics.
     The authors demonstrate a novel technique of fabricating organic
AB
     light-emitting devices. Each device consists of 1480
     micro-pixels, with a pixel dimension of 45x45 \mu m2. The pixels were
     obtained by using a single-step UV patternable sol-gel hybrid
     glass thin film. Due to higher fields, micro-pixels based
     devices show forward light output at lower voltage than conventional
     devices. More than 1% in external quantum efficiency and green light
     exceeding 27,000 cd/m2 are demonstrated.
     73-5 (Optical, Electron, and Mass Spectroscopy and Other Related
CC
     Properties)
     Section cross-reference(s): 36
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- ST LED TPD hydroxyquinoline aluminum sol gel trimethoxysilyl propyl methacrylate; electroluminescent device sol gel polymer TPD hydroxyquinoline aluminum
- IT **Electroluminescent** devices

Sol-gel processing

(hybrid sol-gel micro-patterning of organic **electroluminescent** devices)

79-41-4D, Methacrylic acid, zirconium complexes, polymer with (trimethoxysilyl)propyl methacrylate 2085-33-8, Hydroxyquinoline aluminum 2530-85-0D, polymer with zirconium methacrylate complexes 7440-67-7D, Zirconium, methacrylic acid complexes, polymer with (trimethoxysilyl)propyl methacrylate, uses 65181-78-4, N,N'-Diphenyl-N,N'-di(3-methylphenyl)benzidine RL: DEV (Device component use); USES (Uses) (hybrid sol-gel micro-patterning of organic electroluminescent devices)

L34 ANSWER 14 OF 22 HCA COPYRIGHT 2004 ACS on STN

129:154550 Thin film light-emitting device and its manufacture. Kido, Junji; Fukui, Toshimi; Toki, Motoyuki (Kansai Shingijutsu Kenkyusho K. K., Japan). Jpn. Kokai Tokkyo Koho JP 10199681 A2 19980731 Heisei, 5 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 1997-13336 19970108.

- The device, having a pair of electrode layers sandwiching an organic fluorescent substance-based light-emitting layer, contains (A) an elec. conductive layer comprising a decomposed compound of a metal alkoxide or a metal salt or (B) an organic-inorg. hybrid elec. conductive layer comprising a decomposed compound of a metal alkoxide or a metal salt and an organic polymer between one of the electrode layers and the light-emitting layer. The device is manufactured by (1) forming an electrode layer comprising an elec. conductive transparent material on a glass substrate, (2) applying a solution containing
- metal alkoxide or the metal salt and the optional polymer to form the conductive layer, and (3) successively coating the conductive layer with the light-emitting layer and the electrode layer. The manufacture method gives the device with improved luminous at low cost.
- IC ICM H05B033-26

ICS H01B001-16; H05B033-10

- 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 Section cross-reference(s): 76
- ST light emitting device elec conductive layer; metal alkoxide light emitting device
- IT Electric conductors

Electroluminescent devices

(manufacture of **electroluminescent** device containing elec. conductive layer)

IT 9011-14-7, Poly(methyl methacrylate)

RL: DEV (Device component use); USES (Uses) (manufacture of **electroluminescent** device containing elec. conductive layer)

1312-43-2P, Indium oxide 1314-13-2P, Zinc oxide, uses 1314-62-1P, Vanadium oxide, uses 1332-29-2P, Tin oxide 13463-67-7P, Titania, uses RL: DEV (Device component use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)

(manufacture of **electroluminescent** device containing elec. conductive layer)

IT 1686-22-2, Triethoxyvanadyl 5593-70-4 94845-38-2, Di-sec-butoxyzinc 124113-06-0, Tetra-sec-butoxytin RL: PEP (Physical, engineering or chemical process); PROC (Process)

(manufacture of **electroluminescent** device containing elec. conductive layer)

L34 ANSWER 15 OF 22 HCA COPYRIGHT 2004 ACS on STN

123:69928 Light-emitting elements of the organic/inorganic hybrid-type and methods for their fabrication. Ogura, Hiroyuki; Hanano, Norifumi; Sugita, Masaya (Yazaki Corp., Japan). Ger. Offen. DE 4440410 Al 19950518, 17 pp. (German). CODEN: GWXXBX. APPLICATION: DE 1994-4440410 19941111. PRIORITY: JP 1993-282699 19931111.

AB Light-emitting devices comprising a metal substrate, an isolating reflection film on the substrate, a phosphor luminescent layer in which the phosphor is dispersed in a binder, a transparent conductive film, and a protective cover layer are described in which the substrate and the transparent conductive layer are connected elec. and the phosphor used in the luminescent layer is a hybrid -type phosphor in which the luminescent component is dispersed through the pores of a porous inorg. material, the pores at least on the surface of the layer being closed by an organic isolating material. Fabrication of the devices includes impregnating the porous material with the appropriate resin.

IC ICM H05B033-12

ICA G09F013-20

CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related
Properties)
Section cross-reference(s): 76

ST electroluminescent device phosphor dispersion porous host

IT Electroluminescent devices

Phosphors

(light-emitting elements of organic/inorg. hybrid-type and methods for their fabrication)

IT Acrylic polymers, uses

Epoxy resins, uses

Fluoropolymers

RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(light-emitting elements of organic/inorg. hybrid-type and methods for their fabrication)

IT 165039-43-0, EL 729

RL: DEV (Device component use); MOA (Modifier or additive use); TEM (Technical or engineered material use); USES (Uses)

(light-emitting elements of organic/inorg. hybrid-type and methods for their fabrication)

IT 1344-28-1, Aluminum oxide, uses 7631-86-9, Silica, uses 9002-89-5D, Poval, cyanoethylated 77466-56-9, Cyanoethyl pullulan 159995-97-8, Aluminum silicon oxide

(light-emitting elements of organic/inorg. hybrid-type and methods for their fabrication)

IT 9004-41-5, Cyanoethyl cellulose

RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(light-emitting elements of the organic/inorg. hybrid-type and methods for their fabrication)

- L34 ANSWER 16 OF 22 HCA COPYRIGHT 2004 ACS on STN
- 122:173156 Postgrowth of a Si contact layer on an air-exposed Sil-xGex/Si single quantum well grown by gas-source molecular beam epitaxy, for use in an electroluminescent device. Kato, Y.; Fukatsu, S.; Shiraki, Y. (IBM Res., Tokyo Res. Lab., Kanagawa, 242, Japan). Journal of Vacuum Science & Technology, B: Microelectronics and Nanometer Structures, 13(1), 111-17 (English) 1995. CODEN: JVTBD9. ISSN: 0734-211X. Publisher: American Institute of Physics.
- A Si contact layer for an electroluminescent (EL) AΒ diode was successfully grown on a Sil-xGex/Si single quantum well (SQW) layer by hybrid Si MBE. The hybrid MBE was performed by growing the Si contact layer in a solid-source MBE chamber after transferring the sample through air from a gas-source MBE (GSMBE) chamber in which the starting SQW layer was initially grown by using Si2H6 and GeH4. The growth characteristics of the hybrid MBE were studied by in situ monitoring of the RHEED. A (2+1) reconstruction was observed even after the sample was exposed to air for ≤15 h on a GSMBE-prepared Si(100) surface. Evidence of the excellent quality of the EL device was provided by the sharpest emission lines, a full width at half maximum of ≈5.5 meV. The spectral features of the EL and photoluminescence are almost identical, and a well-resolved acoustic phonon replica was observed Linear polarization for a no-phonon replica of EL was observed along SQW plane.
- CC 73-5 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 Section cross-reference(s): 76
- ST silicon germanium silicide MBE electroluminescent device
- IT Luminescence, electro-(of air-exposed germanium silicide/silicon single quantum well grown by gas-source MBE)
- IT **Electroluminescent** devices
 (silicon postgrowth of contact layer on air-exposed germanium silicide/silicon single quantum well grown by gas-source MBE for use in)
- IT 37380-03-3 80043-06-7
 RL: DEV (Device component use); PRP (Properties); USES (Uses)
 (silicon postgrowth of contact layer on air-exposed silicon single quantum well grown by gas-source MBE for use in electroluminescent device with)
- L34 ANSWER 17 OF 22 HCA COPYRIGHT 2004 ACS on STN

 118:90408 Manufacture of electroluminescent-emitter/photodetector
 hybrids for image pickup devices. Murakami, Hironori; Funada, Masao;
 Yamada, Kiichi (Fuji Xerox Co., Ltd., Japan). Jpn. Kokai Tokkyo Koho JP
 04126390 A2 19920427 Heisei, 12 pp. (Japanese). CODEN: JKXXAF.
 APPLICATION: JP 1990-330584 19901130. PRIORITY: JP 1990-126976 19900518.
- The photocopier element typically comprises: a manuscript (1), a platen (2), a 1st electrode (3) layer, a layer (4) consisting of alternating domains of an electroluminescent phosphor (5) and a window material (6), a 2nd electrode (7) layer, an adhesive (8) layer, and a photodetector (9) layer, wherein 2, 3, 6, and 8 are transparent; 3-7 and 9 are formed patternwisely; 5 emits the light which is reflected by 1, travels through 6-8 and then is detected by 9; and 4/5 are

```
formed by thick-film hybrid screen printing.
     Alternative device elements and manufacturing particulars are also claimed.
The
     thick-film-printing method produces versatile hybrids with markedly
     improved throughputs.
IC
     ICM H05B033-00
         B41J002-44; B41J002-45; B41J002-455; H01L027-15; H04N001-04;
          H05B033-10
     73-11 (Optical, Electron, and Mass Spectroscopy and Other Related
     Properties)
     Section cross-reference(s): 74
     electroluminescent thick film printing phosphor ink; thick film
     printed electroluminescent photodetector hybrid; image scanner
     printed electroluminescence photodetector hybrid
IT
     Polyoxymethylenes, uses
     RL: USES (Uses)
        (binders, in thick-film phosphor inks, for electroluminescent
        -emitter/photodetector hybrid image-sensor manufacture)
TT
     Electroluminescent devices
        (hybrids with with photodetectors, for image sensors)
IT
     Optical imaging devices
        (thick-film-printed electroluminescent-emitter/photodetector
        hybrids for)
     1314-98-3, Zinc sulfide (ZnS), uses
ΙT
     RL: USES (Uses)
        (electroluminescent thick-film phosphor inks from, for
        emitter/detector-hybrid image sensors)
IT
     7440-21-3, Silicon, uses
     RL: USES (Uses)
        (thick-film-printed hybrid imagesensors containing,
        with electroluminescent emitters, in image sensors)
L34 ANSWER 18 OF 22 HCA COPYRIGHT 2004 ACS on STN
115:275242 Chemiluminescence-based static and flow cytometry. Bronstein,
     Irena Y.; Voyta, John C. (Tropix, Inc., USA). U.S. US 5032381 A
     19910716, 15 pp. (English). CODEN: USXXAM. APPLICATION: US
     1988-286725 19881220.
AΒ
     Individual cells and subcellular particulates may be analyzed, or detected
     and separated, without the need for an external energy source by reacting
     endogenous or added components of cells and other particulate matter with
     added thermally, chemical, electrochem., photochem. or enzymically
     decomposable chemiluminescent compds. to produce optically detectable
     light energy emissions. White blood cells were fixed
    with formalin and then incubated sequentially with solution 1 (Na2CO3 buffer,
    pH 9.5 containing MgCl2); solution 2 (solution 1 +
3-(2'-adamantyl)-4-methoxy-4-(3''-
    phosphoryloxy)phenyl-1,2-dioxetane [AMPPD]); solution 2 + Na fluorescein; and
    solution 2 + BDMQ chemiluminescence enhancer and Na fluorescein. Aliquots of
     the cell suspension were then placed on a glass fiber membrane and the
    membrane were sandwiched between 2 pieces of Mylar film into a camera
    luminometer. The light resulting from 1-min exposures was imaged on
    Polaroid Type 612 film. Images of single neutrophils and colonies of
    cells are shown. The neutrophils are rich in alkaline phosphatase that
    catalyzes decomposition of AMPPD. Figures show schematic representations of
    flow cytometers and images produced.
    ICM G01N031-00
```

NCL 424009000

ICS G01N033-48; G01N033-15; G01N033-53

- CC 9-5 (Biochemical Methods)
- IT Slides

(microscope, HEP2 cell fixation to, in in situ hybridization assay and film imaging)

- L34 ANSWER 19 OF 22 HCA COPYRIGHT 2004 ACS on STN
- 114:194869 Optical and electrical properties of gallium arsenide light
 -emitting diodes grown on silicon substrates by a hybrid method
 of molecular beam and liquid phase epitaxies. Yazawa, Y.; Minemura, T.;
 Asano, J. (Hitachi Res. Lab., Hitachi, Ltd., Hitachi, 319-12, Japan).
 Applied Physics Letters, 58(12), 1292-4 (English) 1991. CODEN:
 APPLAB. ISSN: 0003-6951.
- AB Light-emitting diodes (LEDs) of GaAs were grown by a hydrid method which combines mol. beam epitaxy and liquid phase epitaxy on Si. The LEDs exhibit a low reverse leakage current and high stability of light intensity with aging compared with MBE-grown LEDs. These results are attributed to a higher crystallinity in the hybrid-grown GaAs layers.
- CC 73-0 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 Section cross-reference(s): 76
- ST gallium arsenide liq phase epitaxy silicon; LED gallium arsenide LPE silicon; zinc gallium arsenide LPE silicon; tellurium gallium arsenide LPE silicon; electroluminescent diode gallium arsenide LPE silicon; crystal structure gallium arsenide LED silicon
- L34 ANSWER 20 OF 22 HCA COPYRIGHT 2004 ACS on STN

 113:94362 A light diffraction nucleic acid hybridization assay. Tsay, Yuh
 Geng; Calenoff, Emanuel; Gustafson, Eric K.; Trebino, Rick; Lee, John
 (Aspen Diagnostics, Inc., USA). Eur. Pat. Appl. EP 350073 A2

 19900110, 16 pp. DESIGNATED STATES: R: AT, BE, CH, DE, ES, FR,
 GB, GR, IT, LI, LU, NL, SE. (English). CODEN: EPXXDW. APPLICATION: EP
 1989-112493 19890707. PRIORITY: US 1988-216691 19880707.
- AB The title assay uses nucleotide sequences as probes in a nucleic acid hybridization diffraction assay, to detect specific sequences in a sample. Diffraction assay methodologies are applied to determine the presence and amount
 - of analyte. A biogrid or biograting provides greatly reduced nonspecific hybridization and binding. A preferred process involves adhering a uniform layer of hybridizing nucleotide sequence on a smooth, solid surface and exposing the surface to UV radiation through a shadow mask with a diffraction grating pattern of lines to selectively deactivate the hybridizing reagent, leaving a biol. diffraction grating design of lines of active hybridizing reagent. The smooth, solid surface is preferably Si. The diffraction hybridizing assay comprises contacting the diffraction biogrid with the sample to permit nucleic acid hybridization; separating the biogrid from the sample; illuminating the biogrid with light from a light source; and determining the light diffracted by the diffraction hybridization assay surface. Thus, human cytomegalovirus single-stranded DNA was immobilized on a Si wafer by the above method, and the wafer was placed on a dipstick. The dipstick was then exposed to a prepared urine sample for 2-3 h and then illuminated with 632.8 nm light from a He-Ne laser. The intensity of diffracted light was then compared to a standard curve. Diagrams of various embodiments are provided.
- IC ICM C12Q001-68

- CC 9-2 (Biochemical Methods)
- L34 ANSWER 21 OF 22 HCA COPYRIGHT 2004 ACS on STN

 110:181209 Readout of doublesided silicon strip detectors with high density integrated electronics. Becker, H.; Cattaneo, P.; Dietl, H.; Hauff, D.; Lange, E.; Lutz, G.; Moser, H. G.; Schwarz, A. S.; Settles, R.; et al. (Werner-Heisenberg-Inst. Phys., Max-Planck-Inst. Phys. Astrophys., Munich, D-8000/40, Fed. Rep. Ger.). IEEE Transactions on Nuclear Science, 36(1, Pt. 1), 246-50 (English) 1989. CODEN: IETNAE. ISSN: 0018-9499.

 AB The readout of double-sided Si strip detectors in colliding beam expts.
- The readout of double-sided Si strip detectors in colliding beam expts. poses severe constraints on the mech. and electronical design. The system is described that was developed for the ALEPH minivertex detector at LEP. The design makes use of capacitively coupled double-sided Si strip detectors and custom designed low noise VLSI CMOS electronics, mounted on ceramic carriers which simultaneously serve as mech. support and substrates for thick film hybrid circuitry. A description of the detector system with its peripheral driving and readout electronics as well as 1st test results with a light source and a particle beam are given.
- CC 71-7 (Nuclear Technology)
- L34 ANSWER 22 OF 22 HCA COPYRIGHT 2004 ACS on STN 104:44061 Additive thin **film** technology for **hybrid** circuit fabrication. Krokoszinski, H. J.; Oetzmann, H.; Gernoth, H.; Schmidt, C.

(Cent. Res. Lab., Brown, Boveri und Cie A.-G., Heidelberg, D-6900, Fed. Rep. Ger.). Journal of Vacuum Science & Technology, A: Vacuum, Surfaces, and Films, 3(6), 2704-7 (English) 1985. CODEN: JVTAD6. ISSN: 0734-2101.

- The techniques of evaporation masking, or evaporation through metal masks, for fabricating thin-film hybrid circuits are described.

 The methods can be used to deposit locally several types of different materials, such as conducting, resistive, semicond., insulating and electroluminescent materials. The possibility of producing complex hybrid circuit in one vacuum cycle using these techniques is discussed. A typical circuit consisting of Cr Al203, Y203 and glass insulators, Nichrome and cermet resistors, and ceramic substrate is described.
- CC 76-3 (Electric Phenomena)

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>>> THE DISPLAY LAYOUT HAS BEEN CHANGED TO ACCOMODATE THE NEW FORMAT GERMAN PATENT APPLICATION AND PUBLICATION NUMBERS. SEE ALSO: http://www.stn-international.de/archive/stnews/news0104.pdf <<<

```
=> d L46 1-3 all
L46 ANSWER 1 OF 3 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
     2004-064594 [07] WPIX
DNN N2004-052290
                       DNC C2004-026574
TI
     Semiconductor light emitting equipment has
     light-transmitting metalloxane gel layer covering semiconductor
     light emitting device anchored to the end of the one
     Wiring conductor.
    A85 E12 L03 U12
     (SANK-N) SANKEN DENKI KK
PΑ
CYC 1
PΤ
     JP 2002134790 A 20020510 (200407)*
                                              10 H01L033-00
ADT JP 2002134790 A JP 2000-323179 20001023
PRAI JP 2000-323179
                         20001023
    ICM H01L033-00
     ICS
         C09K011-80
AΒ
    JP2002134790 A UPAB: 20040128
     NOVELTY - Semiconductor light emitting equipment has a
     pair of wiring conductors, a semiconductor light
     emitting device anchored to the end of the one wiring conductor,
     and a light-transmitting metalloxane gel layer for covering the
```

semiconductor light emitting device. DETAILED DESCRIPTION - Semiconductor light emitting equipment has a pair of wiring conductors, a semiconductor light emitting device anchored to the end of the one wiring conductor, and a light-transmitting metalloxane gel layer for covering the semiconductor light emitting device. The metalloxane gel layer contains a fluorescent material having light transmission to blue light irradiated from the semiconductor light emitting device and absorbing the blue light irradiated from the light emitting device to convert the blue light into yellow light. The metalloxane gel layer is formed of a metalloxane sol obtained by applying hydrolytic polymerization to a metal alkoxide, or a metalloxane sol obtained by applying hydrolytic polymerization to an inorganic/organic complex consisting of a metal alkoxide and an organic resin, or a metalloxane sol consisting of a ceramic precursor polymer. The metalloxane gel layer firmly sticks the semiconductor light emitting device to the wiring conductors. The fluorescent material consists of (Y1-x, Gdx) 3 (Al1-y, Gay) 5012: CezPrw.

```
x = 0 - 0.5;

y = 0 - 0.5;

z = 0.001 - 0.5;

w = 0.001 - 0.5.
```

An INDEPENDENT CLAIM is included for the production of the semiconductor light emitting equipment, comprising:

```
(a) forming a cup portion on the end of one wiring conductor of a
pair of wiring conductors;
```

- (b) fixing the semiconductor light emitting
- device to the bottom of the cup portion;
- (c) electrically connecting electrodes formed on the upper surface of the semiconductor light emitting device to the pair of wiring conductors by means of bonding wires;
- (d) filling the fluorescent material and the metalloxane sol in the cup portion;
- (e) covering the semiconductor light emitting device, the electrodes, and the ends of the bonding wires connected to the electrodes;
- (f) drying/heating curing the metalloxane sol to form the metalloxane
 gel layer; and
- (g) encapsulating the metalloxane gel layer by means of an encapsulating resin

The metalloxane gel layer is firmly stuck to the semiconductor light emitting device and the wiring conductors.

USE - The semiconductor **light emitting** equipment applies wavelength conversion to the light irradiated from the semiconductor **light emitting** device to outwardly release the light.

ADVANTAGE - The semiconductor light emitting device and the fluorescent material are surrounded by the metalloxane gel layer having stability under short wavelength light irradiation. The semiconductor light emitting equipment has enhanced resistance to environment. The semiconductor light emitting equipment has color rendering properties by using a host as garnet structure yttrium aluminum garnet and by using the Ce as an

activator and the Pr as a co-activator.

DESCRIPTION OF DRAWING(S) - The drawing shows the semiconductor

light-emitting-device (20).

Semiconductor light-emitting-element 2

Electrode (2a) of the cathode side of semiconductor

light-emitting-element 2a
 Wiring-conductor 3

Cup part 3a

Bottom-part of cup part 3b

Bonding wire 5

Dwg.1/9

FS CPI EPI

FA AB; GI; DCN

MC CPI: A06-D; A09-A02; A11-B05; A11-C02; A12-E04; A12-E07C; A12-E11A; E34-E; L04-E03

EPI: U12-A01

L46 ANSWER 2 OF 3 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN

AN 2002-727091 [79] WPIX

DNN N2002-573413 DNC C2002-206369

Compositions for forming metal oxide thin films useful in the production of dielectric layers consist of polyvinyl acetamides, alkoxides of titanium or zirconium, and bivalent alkaline earth metal salts, dispersed in solvents.

DC A85 L03 V01 W02 X12

PA (DENK) TDK CORP

CYC 1

PI JP 2002255553 A 20020911 (200279)* 10 C01G023-04

ADT JP 2002255553 A JP 2001-56978 20010301

```
PRAI JP 2001-56978
                           20010301
     ICM C01G023-04
     ICS C01G025-00; C04B035-46
AB
     JP2002255553 A UPAB: 20021209
     NOVELTY - A composition for forming a metal oxide thin film consists of a
     hydrophilic polymer, a metal alkoxide, and a metallic salt, which are
     dispersed in a solvent, the metal in the metallic salt is a bivalent
     alkaline earth metal, the metal in the metal alkoxide is Ti or Zr, the
     solvent contains a chelating agent, and the hydrophilic polymer is a
     polyvinyl acetamide.
          DETAILED DESCRIPTION - An INDEPENDENT CLAIM is also included for
     metal oxide thin films with thickness of at least 0.5 mu m which are made
     from the claimed compositions.
          USE - The compositions for forming metal oxide thin films obtained
     can be used to form dielectric layers for multilayer ceramic
     capacitors, hybrid IC circuits, composite LC network circuits,
     and thin film EL devices.
          ADVANTAGE - The compositions obtained remain stable for a long time
     and can be used to form thick films.
     Dwg.0/11
FS
     CPI EPI
FΑ
     AΒ
     CPI: A04-D; A08-A07; A08-S02; A12-E07; L03-B03F; L03-G05F
MC
     EPI: V01-B03A1; W02-A08C; X12-E01A
L46 ANSWER 3 OF 3 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
     2002-313574 [35]
AN
                        WPIX
     Ac-dc hybrid type thin film electroluminescent
TI
     device.
DC
     U14 X26
ΙN
     KIM, Y S; PARK, S H; YOON, S J
     (KOEL-N) KOREA ELECTRONICS & TELECOM RES INST
PA
CYC
     KR 2001062973 A 20010709 (200235)*
PΤ
                                                      H05B033-14
     KR 319766
                    B 20020105 (200253)
                                                      H05B033-14
     KR 2001062973 A KR 1999-59759 19991221; KR 319766 B KR 1999-59759 19991221
ADT
    KR 319766 B Previous Publ. KR 2001062973
PRAI KR 1999-59759
                          19991221
     ICM H05B033-14
ΙC
     KR2001062973 A UPAB: 20020603
     NOVELTY - An AC-DC hybrid type thin film EL(
    ElectroLuminescence) is provided to emit natural colors of high
    purity and high brightness and enhance the emission efficiency by
     selecting a drive circuit suitable to the luminescence characteristics
     according to respective colors.
          DETAILED DESCRIPTION - An AC drive type single EL for
    emitting a plurality of colors and a DC drive type single EL for
    emitting a plurality of colors are formed on one substrate(11).
    The AC drive type single EL comprises a transparent anode(12), a
    fluorescent layer(13), an electron supply and electron acceleration
    layer(14) and a metal cathode(16) sequentially formed in their order. The
    DC drive type single EL comprises a transparent anode(12), a
    lower insulating layer(17), a fluorescent layer(13), an upper insulating
    layer(18) and a metal cathode(16).
    Dwg.1/10
```

EPI: U14-J; X26-J

FS

FΑ

MC

EPI

AB; GI

- => d L80 1-12 ti
- L80 ANSWER 1 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Barrier property laminated film for packaging use, comprises inorganic and organic hybrid polymer layer which has polymer with hydrogen bond formation group and metallic oxide.
- L80 ANSWER 2 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN TI Laminate useful for wrapping foods and drinks, medical supplies, or electronic members has enhanced gas barrier, heat resistance, mechanical strength.
- L80 ANSWER 3 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Semiconductor light-emitting device and its manufacture.
- L80 ANSWER 4 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Information recording and reproducing device for hybrid card has contact TItype integrated circuit head, provided on mounting surface of recess, that contacts IC portion of IC card to enable recording and reproduction of information.
- L80 ANSWER 5 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Mask membrane material mfg method used in X-ray lithography involves TΤ formation of silicon carbide and hybrid films of silicon nitride over substrate, using target consisting of silicon carbide compact and silicon nitride compact.
- L80 ANSWER 6 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Light emitting element e.g. LED of UV wavelength comprises sapphire substrate, aluminium nitride buffer layer, and p-type and n-type indium gallium nitride current dispersion and diffusion hybrid crystal.
- L80 ANSWER 7 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Identifying and classifying surface qualities and defects of object -TI using video camera to store reflected images arising from sequential exposure to light from distributed sources.
- L80 ANSWER 8 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Light source identifier used in atomic absorption TI spectrometer - uses electronic coding read out in series according to beat pulse sequence corresp. to cavity cathode lamp.
- L80 ANSWER 9 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Optical reader for camera film cartridges has hybrid ΤI circuit, mounted adjacent cartridge chamber and including window to direct light from emitters to photosensors.
- L80 ANSWER 10 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Hybrid thin-film integrated circuit mfr. uses several light sources patterning photoresist layer on thin metal coated substrate.
- L80 ANSWER 11 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
- Optical microcircuit printing process is for exposing to ultra-violet

light semiconductor or coated hybrid substrate.

```
ANSWER 12 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
     Optical micro cct. printing with elimination of Fresnel diffraction -
TТ
     using light integrator comprising two successive lenticular matrices.
=> d L80 1,3,6,9-11 all
L80 ANSWER 1 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
AN
     2003-472191 [45]
                        WPIX
DNN N2003-375667
                        DNC C2003-126375
     Barrier property laminated film for packaging use, comprises inorganic and
     organic hybrid polymer layer which has polymer with
     hydrogen bond formation group and metallic oxide.
     A92 G02 P42 P73 U11 U12 U14 X15 X16 X26
PΑ
     (NIPQ) DAINIPPON PRINTING CO LTD
CYC 1
     JP 2002301793 A 20021015 (200345)*
PI
                                               17
                                                      B32B027-18
ADT JP 2002301793 A JP 2001-96670 20010329
PRAI JP 2001-24461
                          20010131
     ICM B32B027-18
          B05D003-06; B05D005-00; B05D007-04; B32B027-00; C08G081-00;
ICI
    C08L101:00
AΒ
     JP2002301793 A UPAB: 20030716
     NOVELTY - The barrier property laminated film has a film base material,
     with organic and inorganic hybrid polymer layer on it.
     The polymer layer has a polymer with hydrogen bond formation group, and
     metallic oxide microparticles dispersed in the polymer. The microparticles
     have an average particle diameter of 100 nm or less.
          DETAILED DESCRIPTION - An INDEPENDENT CLAIM is included for
     manufacturing method of barrier property laminated film.
          USE - For packaging of food/beverage products, pharmaceuticals, solar
     cell, polymer battery, liquid crystal film, organic
     electroluminescence element and electronic components.
          ADVANTAGE - The film has excellent gas barrier property and
     transparency. Since the average particle diameter of the microparticles is
     less than 100 nm, cross-linked structure of polymer is effectively formed.
     Dwg.0/0
     CPI EPI GMPI
FS
FΑ
     AB
MC
     CPI: A11-B09A2; A12-P01A; G02-A05
     EPI: U11-C05B9A; U12-A02A4D; U14-J02B; U14-J02D2; U14-K01A4A; X15-A02;
          X16-F09; X26-J
L80 ANSWER 3 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
ΑN
     2002-033057 [04]
                        WPTX
DNN N2002-025390
                        DNC C2002-009142
     Semiconductor light-emitting device and its
     manufacture.
DC
     L03 U12
IN
     WANG, T; WANG, T Y
     (WANG-I) WANG T; (WANG-I) WANG T Y
PA
CYC 2
                    A 20010528 (200204)*
PΙ
    TW 437104
                                                      H01L033-00
     US 6469324
                   B1 20021022 (200273)
                                                      H01L033-00
    TW 437104 A TW 1999-109388 19990605; US 6469324 B1 Provisional US
```

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1999-135946P 19990525, US 2000-577446 20000524
PRAI US 1999-135946P 19990525; US 2000-577446
                                                         20000524
     ICM H01L033-00
AΒ
          437104 A UPAB: 20020117
     NOVELTY - A semiconductor light emitting device
     comprises an AlGaInP lower confining layer, an AlGaInP active layer, an
     AlGaInP upper confining layer and a window layer on the upper confining
     layer using the MOVPE process. The device further contains a
     hybrid antireflection layer on the top surface and a
     lower conductive reflector at the substrate interface. The light
     emitting device has a high surface light-extraction efficiency due
     to reduced substrate absorption loss and light piping. The hybrid
     antireflective layer contains at least a conductor layer for
     uniform current injection and an oxide layer for light extraction and
     environmental stability. The device structure contains a hybrid
     conductive transparent layer on the top surface and a conductive
     lower reflecting layer. Advantages of the LED include highly efficient
     current-spreading and surface light extraction.
     Dwg.1/1
FS
     CPI EPI
FA
     AB; GI
MC
     CPI: L04-A02C; L04-E03
     EPI: U12-A01A
L80 ANSWER 6 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
     1996-352433 [35] WPIX
DNN N1996-297302
                        DNC C1996-111152
     Light emitting element e.g. LED of UV wavelength -
     comprises sapphire substrate, aluminium nitride buffer layer, and p-type
     and n-type indium gallium nitride current dispersion and diffusion hybrid
    crystal.
DC
    L03 U12 V08
PA
    (HITD) HITACHI CABLE LTD
CYC 1
PΙ
     JP 08167735
                   A 19960625 (199635)*
                                               6 H01L033-00
ADT JP 08167735 A JP 1994-307430 19941212
PRAI JP 1994-307430
                          19941212
    ICM H01L033-00
     ICS H01S003-18
AΒ
     JP 08167735 A UPAB: 19960905
     The light emitting element consists of a sapphire
     substrate (7) on which an AlN buffer layer (6) is formed. A N type InGaN
     current dispersing layer (5), a N type InGaN clay layer (4), a InGaN
     active layer (2) and a P type InGaN current diffusion layer (1) are
     sequentially formed on the buffer layer. The GaN hybrid
     crystal ratio of the active layer and the current diffusion layer are set
     to 0.6 and 0.7 respectively.
          Thus, the hybrid crystal ratio, difference is made to be lesser than
     or equal to 0.2 making the composition of the current diffusion layer near
     the composition of an active layer.
          ADVANTAGE - Develops light emitting layer with
     high intensity. Enables to grow up good active layer. Provides green and
    blue light with very high brightness.
     Dwg.1/4
    CPI EPI
FS
FΑ
    AB; GI
MC
    CPI: L04-A02; L04-E03A; L04-E03B
     EPI: U12-A01A1A; U12-A01B1; V08-A04A
```

```
L80 ANSWER 9 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
     1985-066604 [11]
                        WPIX
DNN N1985-049751
     Optical reader for camera film cartridges - has hybrid
     circuit, mounted adjacent cartridge chamber and including window to direct
     light from emitters to photosensors.
DC
     P82 S06
PA
     (EAST) KODAK LTD
CYC 1
PΙ
     RD 250022
                     A 19850210 (198511)*
PRAI RD 1985-250022
                        19850120
ΙC
     G03B000-01; G06K000-01
AΒ
           250022 A UPAB: 19930925
     The reader comprises a photo emitter and receiver element for each area of
     code pattern on a film cartridge. The emitter/receiver pairs are mounted
     on a substrate to form a hybrid circuit which pref. also includes a logic
     integrated circuit to process the signals into a usable form. The reader
     is mounted in a camera and the output from the logic integrated circuit
     controls functions of the camera such as exposure or film counting.
          The hybrid circuit is mounted in a camera adjacent a cartridge
     chamber and includes a clear window comprising prisms or lenses to control
     the emitted light and the reflected light to direct
     light from the emitters to the code pattern areas and
     receive reflected light to the respective photosensitive receivers. To
     reduce battery drain the hybrid circuit operates intermittently, such as
     only when a camera shutter is released. To reduce loading on the battery,
     the photo-emitters is operated sequentially.
     EPI GMPI
FS
FΑ
     AB
MC
     EPI: S06-B02
L80 ANSWER 10 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
     1982-B9670E [08]
AN
                        WPIX
     Hybrid thin-film integrated circuit mfr. - uses
     several light sources patterning photoresist layer on
     thin metal coated substrate.
DC
     P84 U11 U14 V04
     (NIDE) NIPPON ELECTRIC CO
     JP 57005390
                     A 19820112 (198208)*
PRAI JP 1980-80036
                          19800613
     G03F007-20; H01L021-30; H05K003-00
     EPI GMPI
FΑ
     NOAB
L80 ANSWER 11 OF 12 WPIX COPYRIGHT 2004 THOMSON DERWENT on STN
ΑN
     1977-E4208Y [21]
                        WPIX
     Optical microcircuit printing process - is for exposing to ultra-violet
     light semiconductor or coated hybrid substrate.
DC
PA
     (TAMA-N) TAMARACK SCI CO INC
CYC
    1
     US 4023904
                     A 19770517 (197721)*
PΙ
PRAI US 1974-484564
                          19740701; US 1976-648370
                                                         19760112
IC
     G03B027-02
          4023904 A UPAB: 19930901
AΒ
     US
     The process is for exposing to ultraviolet light a semiconductor or
```

hybrid substrate coated with photo-resist, in back of a mask having bars and very narrow slits, the diffraction patterns ordinarily experienced at the substrate being virtually eliminated through use, between the light source and the mask, of a light integrator comprised of two successive matrixes of very small lenses or lenticules.

The lenticules form a large number of magnified, superimposed, slightly displaced images of the light source in the plane of the substrate; and when the slitted mask is interposed, this light forms a large number of diffraction patterns on the substrate which, because of their large number, superimposition, and slight displacement, results in extreme uniformity of light intensity and sharp resolution throughout the pattern of light on the substrate.

FS GMPI

FA AB

=> file japio FILE 'JAPIO' ENTERED AT 09:16:24 ON 12 AUG 2004 COPYRIGHT (C) 2004 Japanese Patent Office (JPO) - JAPIO

FILE LAST UPDATED: 2 AUG 2004 <20040802/UP> : FILE COVERS APR 1973 TO APRIL 30, 2004

<<< GRAPHIC IMAGES AVAILABLE >>>

=> d L58 1-10 ti

- L58 ANSWER 1 OF 10 JAPIO (C) 2004 JPO on STN

 TI ORGANIC-INORGANIC POLYMER HYBRID FILM, TRANSPARENT
 ELECTRIC CONDUCTIVE FILM CONSISTING OF ORGANIC-INORGANIC POLYMER
 HYBRID FILM, LIQUID CRYSTAL DISPLAY, ORGANIC EL
 DISPLAY AND TOUCH PANEL
- L58 ANSWER 2 OF 10 JAPIO (C) 2004 JPO on STN
 TI MELTING PROCESSING AT LOW TEMPERATURE OF ORGANIC/ INORGANIC HYBRID
 FILM
- L58 ANSWER 3 OF 10 JAPIO (C) 2004 JPO on STN TI CIRCUIT BOARD FILM AND METHOD OF ITS MANUFACTURE
- L58 ANSWER 4 OF 10 JAPIO (C) 2004 JPO on STN
- TI MANUFACTURE OF MASKING MEMBRANE MATERIAL FOR X-RAY LITHOGRAPHY
- L58 ANSWER 5 OF 10 JAPIO (C) 2004 JPO on STN
- TI ELECTROLUMINESCENT ELEMENT
- L58 ANSWER 6 OF 10 JAPIO (C) 2004 JPO on STN
 TI COLOR CHANGING HYBRID VESICLE CONTENT HAVING PHOTO
- TI COLOR CHANGING HYBRID VESICLE CONTENT HAVING PHOTORESPONSIVE FILM AND OPTICAL CONTROL METHOD FOR COLOR CHANGE THEREOF
- L58 ANSWER 7 OF 10 JAPIO (C) 2004 JPO on STN
- TI DOUBLE TUBE TYPE METAL HALIDE DISCHARGE LAMP FOR ILLUMINATION USE
- L58 ANSWER 8 OF 10 JAPIO (C) 2004 JPO on STN
- TI ELECTROLUMINESCENCE ELEMENT
- L58 ANSWER 9 OF 10 JAPIO (C) 2004 JPO on STN

ΤI LIGHT EMITTING DIODE

L58 ANSWER 10 OF 10 JAPIO (C) 2004 JPO on STN SEMICONDUCTOR LIGHT EMITTING DEVICE

=> => d L83 ibib abs ind

L83 ANSWER 1 OF 9 JAPIO (C) 2004 JPO on STN

ACCESSION NUMBER: 2004-075951 JAPIO

TITLE:

ORGANIC-INORGANIC POLYMER HYBRID

FILM, TRANSPARENT ELECTRIC CONDUCTIVE FILM CONSISTING OF ORGANIC-INORGANIC POLYMER HYBRID

FILM, LIQUID CRYSTAL DISPLAY, ORGANIC

EL DISPLAY AND TOUCH PANEL

INVENTOR:

OKUBO YASUSHI; TAKAGI TAKAHIRO; KURACHI IKUO

PATENT ASSIGNEE(S):

KONICA MINOLTA HOLDINGS INC

PATENT INFORMATION:

PATENT NO KIND DATE ERA MAIN IPC JP 2004075951 A 20040311 Heisei C08L001-14

APPLICATION INFORMATION

STN FORMAT: JP 2002-241869

20020822

ORIGINAL:

JP2002241869

Heisei

PRIORITY APPLN. INFO.: JP 2002-241869 20020822

SOURCE:

PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined

Applications, Vol. 2004

ΑN 2004-075951 JAPIO

PROBLEM TO BE SOLVED: To provide a flexible substrate film having a high transparency and heat resistance, and less birefringence, and useful for a liquid crystal display, an organic EL display or a touch panel. SOLUTION: This organic-inorganic polymer hybrid film consisting of a cellulose ester and a hydrolytic polycondensate of a reactive metal compound capable of performing the hydrolytic polycondensation is characterized by having 0.1-40 mass % mass of the film based on the total mass of the organic-inorganic polymer hybrid film-supporting material on assuming that the hydrolytic polycondensation reaction of the reactive metal compound is completed as shown in formula (1) shown below. Formula (1): A<SB>p</SB>M<SB>q</SB>SS>r</SB> → A<SB>p</SB>M<SB>q</SB>0<SB>r/2</S B>.

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ICM C08L001-14 IC

ICS B32B007-02; B32B009-00; B32B023-20; C08J005-18; C08L083-04;

C08L085-00; G02B001-10

ICA H01B005-14; H01H001-02

=> d L83 2-10 ibib abs ind

L83 ANSWER 2 OF 9 JAPIO (C) 2004 JPO on STN

ACCESSION NUMBER:

2003-309308 JAPIO

TITLE:

MELTING PROCESSING AT LOW TEMPERATURE OF ORGANIC/

INORGANIC HYBRID FILM

INVENTOR:

DEHAVEN PATRICK W; MEDEIROS DAVID R; MITZI DAVID B

PATENT ASSIGNEE(S):

INTERNATL BUSINESS MACH CORP < IBM>

PATENT INFORMATION:

KIND DATE PATENT NO ERA MAIN IPC ______ JP 2003309308 A 20031031 Heisei H01L051-00

APPLICATION INFORMATION

STN FORMAT: JP 2003-62285 200303
ORIGINAL: JP2003062285 Heisei
PRIORITY APPLN. INFO:: US 2002-94351 20020308 20030307 Heisei

SOURCE: PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined

Applications, Vol. 2003

AN 2003-309308 JAPIO

AΒ PROBLEM TO BE SOLVED: To provide an inexpensive organic/inorganic hybrid material for melting processing which can be used for various use, including a light emission layer and a charge transfer layer of a flat panel display, a non-linear light/ photoconductive device, a chemical sensor, and an organic/inorganic light emitting diode, and a channel layer of an organic/inorganic thin film transistor and an organic/inorganic field-effect transistor. SOLUTION: The method, which is for manufacturing the organic/inorganic hybrid material for melting processing and which contains a step for maintaining the solid organic/inorganic hybrid material, at a temperature higher than the melting point of the organic/inorganic hybrid material but lower than its decomposition temperature, for a period of time sufficient to form a uniformly melt article and the step after that which cools down the uniformly melt article at ambient temperature, with sufficient conditions to generate the organic/ inorganic hybrid material for melting processing, is provided.

COPYRIGHT: (C) 2004, JPO

IC ICM H01L051-00

ICS H01L021-336; H01L029-78; H01L029-786

L83 ANSWER 3 OF 9 JAPIO (C) 2004 JPO on STN ACCESSION NUMBER: 2002-194228 JAPIO

TITLE: INVENTOR:

CIRCUIT BOARD FILM AND METHOD OF ITS MANUFACTURE YAMADA TAKETOSHI; KITA HIROSHI; SAITO KOICHI; OKUBO

YASUSHI

PATENT ASSIGNEE(S):

KONICA CORP

PATENT INFORMATION:

PATENT NO KIND DATE ERA MAIN IPC ____________ JP 2002194228 A 20020710 Heisei C08L101-00

APPLICATION INFORMATION

STN FORMAT: JP 2000-392502 2000122 ORIGINAL: JP2000392502 Heisei 20001225 PRIORITY APPLN. INFO.: JP 2000-392502 Helsel
20001225
SOURCE: PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined

Applications, Vol. 2002

AN 2002-194228 JAPIO

AB PROBLEM TO BE SOLVED: To provide a circuit board film for an electron display element, electron optical element, touch panel, or solar cell, having high transparency and small moisture permeability, especially, a circuit board film for an electron display element suitable for an organic EL element, a liquid crystalline panel, etc. SOLUTION: This circuit board film for an electron display element,

electron optical element, touch panel, or solar cell is an organic/inorganic polymer hybrid film mainly containing an organic polymer having a solubility at 25°C to 100 g water of mot less than 0 g but not higher than 5 g, and that to 100 gacetone of not less than 25 g but not higher than 100 g, and a reactive metal compound capable of hydrolysis polycondensation or its hydrolysis polycondensate.

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IC ICM C08L101-00

ICS C08J005-18; G09F009-30; H01L031-04; H05B033-02; H05B033-14

L83 ANSWER 4 OF 9 JAPIO (C) 2004 JPO on STN 1994-140157 JAPIO ACCESSION NUMBER:

TITLE:

ELECTROLUMINESCENT ELEMENT

INVENTOR:

ANZAKI TOSHIAKI; YOSHII TETSURO; AOKI YUICHI

PATENT ASSIGNEE(S):

NIPPON SHEET GLASS CO LTD

PATENT INFORMATION:

PATENT NO	KIND	DATE	ERA	MAIN IPC
JP 06140157	A	19940520	Heisei	H05B033-22

APPLICATION INFORMATION

STN FORMAT: ORIGINAL:

JP 1992-291814 19921029 JP04291814 Heisei

PRIORITY APPLN. INFO.: JP 1992-291814

19921029

SOURCE:

PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined

Applications, Vol. 1994

1994-140157 JAPIO NA

PURPOSE: To enhance light emitting efficiency and AΒ solve printing failure by setting a current dispersing layer to a layer having a predetermined continuity threshold voltage and ohmic resistance characteristic, and using a conductive fine powder having low temperature dependency of resistivity as a current limiting layer. CONSTITUTION: On a transparent glass base 7, a transparent

electrode 1, a light emitting layer 2, an

electron barrier layer 3, a current dispersing layer 4, a current limiting layer 5 having a conductive fine powder dispersed and fixed by an organic resin, and a back plate 6 are successively laminated. The current dispersing layer 4 is set to a layer having continuity threshold voltage less than 10V and ohmic resistance characteristic. As the conductive fine powder, fine powder of a semiconductor or metal having a resistivity of 3×10<SP>3</SP>-1×10<SP>6</SP>Ωcm and the temperature dependency of the resistivity of -0.5%/K or layer is used. According to this constitution, a DC-drivable thin film-powder hybrid

electroluminescent element which has both high light

emitting efficiency necessary for a display device for character and pattern and the characteristic of never causing a character residual printing at the time of stopping the light emission of the element can be provided.

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ICM H05B033-22 ICICS H05B033-26

L83 ANSWER 5 OF 9 JAPIO (C) 2004 JPO on STN ACCESSION NUMBER: 1993-158010 JAPIO

COLOR CHANGING HYBRID VESICLE CONTENT HAVING

TITLE:

PHOTORESPONSIVE FILM AND OPTICAL CONTROL METHOD FOR

COLOR CHANGE THEREOF

INVENTOR:

PATENT ASSIGNEE(S):

SHIOTANI MASAHARU CASIO COMPUT CO LTD

PATENT INFORMATION:

PATENT NO KIND DATE ERA MAIN IPC JP 05158010 A 19930625 Heisei G02F001-13

APPLICATION INFORMATION

STN FORMAT: ORIGINAL:

JP 1991-323322

19911206

ORIGINAL: JP03323322 Heisei
PRIORITY APPLN. INFO.: JP 1991-323322 19911206
SOURCE: PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined

Applications, Vol. 1993

ΑN 1993-158010 JAPIO

AΒ PURPOSE: To provide the color changing hybrid vesicle content which can be easily pulverized, has excellent dynamic strength and can easily and densely control the color change based on the interdiffusion of dye precursors and color developers and the optical control method for the color change thereof.

CONSTITUTION: The vesicle film Vf forming the hybrid vesicle HV is made into the film structure in which a low-molecular bimolecular film 2 is fixed and supported by a polymerized high-polymer bimolecular film 1. The hybrid vesicle content formed by dissolving the color developers 4 into a solvent 5, sealing the solvent formed into the internal phase of the vesicle and incorporating the dye precursors 6 dissolved in the solvent 5 into the external phase of the vesicle is charged into a transparent container 7. A 1st light

source 8 and 2nd light source 9 which

irradiate the content with 1st light R1 and 2nd light R2 respectively including specific wavelengths ν 1, ν 2 for isomerizing the photoisomerizing material associated into the low molecule bimolecular film 2 are disposed on the outside of the container 7. COPYRIGHT: (C) 1993, JPO& Japio

ICM G02F001-13

ICS B01J013-00; B01J013-02; C07C245-08; C09K009-02

ICA G03G009-08

L83 ANSWER 6 OF 9 JAPIO (C) 2004 JPO on STN ACCESSION NUMBER: 1992-133256 JAPIO
TITLE: DOUBLE TUBE TYPE METAL HALIDE DISCI
ILLUMINATION USE
INVENTOR: KASAI YOSHIHIRO; OKAMOTO TOSHIYUKI

DOUBLE TUBE TYPE METAL HALIDE DISCHARGE LAMP FOR

PATENT ASSIGNEE(S): USHIO INC

PATENT INFORMATION:

PATENT NO KIND DATE ERA MAIN IPC JP 04133256 A 19920507 Heisei H01J061-35

APPLICATION INFORMATION

STN FORMAT: JP 1990-254231 19900926
ORIGINAL: JP02254231 Heisei
PRIORITY APPLN. INFO:: JP 1990-254231 19900926
SOURCE: PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined

Applications, Vol. 1992

1992-133256 JAPIO

PURPOSE: To have light emission with stable color temperature by coating the surface of an outer tube with a transparent film consisting of Ti oxide and Si oxide and having a thickness over 50nm, wherein the mol ratio ranges 6:4 thru 2:8, and including a fine powder of ceramic material in this transparent film in such a way as well dispersed. CONSTITUTION: A transparent film F consisting of Ti oxide and Si oxide is formed on the surface of an outer tube 20. This hybrid film F shall be in composition such that the mol ratio of Ti oxide to Si oxide ranges 6:4 thru 2:8, and ceramic material fine powder of Si oxide etc., is dispersed therein. The film F shall have a thickness over 50nm, and particle sizes of fine powder of Si oxide preferably lie between 0.1μ m and several μ ms. The light penetrating the film F is diffused by the fine powder of ceramic material as dispersed in the film F, so that well mixed light with high uniformity is obtained. This enables relieving chromatic unevenness and illuminance unevenness in the region not irradiated with light in satisfactory performance. COPYRIGHT: (C) 1992, JPO&Japio

IC ICM H01J061-35 ICS H01J061-34

· L83 ANSWER 7 OF 9 JAPIO (C) 2004 JPO on STN

ACCESSION NUMBER:

1990-056898 JAPIO

TITLE: INVENTOR: **ELECTROLUMINESCENCE** ELEMENT

KOBAYASHI SHIRO; AOKI YUICHI; NAKANISHI KOJI; OGINO

ETSUO; SHIGEOKA TOSHITAKA; ENJOJI KATSUHISA

PATENT ASSIGNEE(S): NIPPON SHEET GLASS CO LTD

PATENT INFORMATION:

PATENT NO KIND DATE ERA MAIN IPC JP 02056898 А 19900226 Heisei H05B033-26

APPLICATION INFORMATION

STN FORMAT:

JP 1988-207830

19880822

ORIGINAL:

JP63207830

Showa

PRIORITY APPLN. INFO.: JP 1988-207830

19880822

SOURCE:

PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined

Applications, Vol. 1990

ΑN 1990-056898 JAPIO

PURPOSE: To prevent the excitation breakdown of a luminous layer due to an AΒ overcurrent by improving the material of MnO<SB>2</SB> and using a current limiting layer with preferable resistivity for a hybrid type electroluminescence EL element.

CONSTITUTION: A transparent electrode 2, a luminous layer 3, a current limiting layer 4 fixed with conducting fine powder by a binder, and a back electrode 5 are provided on a transparent insulating base 1. A mixture of α type MnO<SB>2</SB> and γ type MnO<SB>2</SB> or δ type MnO<SB>2</SB> is used as the conducting fine powder of the current limiting layer. The resistivity of the current limiting layer of a hybrid type EL element

can be set to the optimum value in the range of latimes; 10<SP>4</SP>Ω .cm-5×10<SP>5</SP>Ω.cm, the breakage of the element due to an overcurrent can be prevented; and an EL display with high reliability can be obtained.

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ICM H05B033-26 IC

ICS H05B033-22

L83 ANSWER 8 OF 9 JAPIO (C) 2004 JPO on STN ACCESSION NUMBER: 1986-161777 JAPIO TITLE: LIGHT EMITTING DIODE

INVENTOR:

MITSUYU TSUNEO; YAMAZAKI OSAMU PATENT ASSIGNEE(S): MATSUSHITA ELECTRIC IND CO LTD

PATENT INFORMATION:

PATENT NO KIND DATE ERA MAIN IPC ______ JP 61161777 19860722 Showa H01L033-00

APPLICATION INFORMATION

STN FORMAT: JP 1985-3517 19850111
ORIGINAL: JP60003517 Showa
PRIORITY APPLN. INFO.: JP 1985-3517 19850111
SOURCE: PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined

Applications, Vol. 1986

AN1986-161777 JAPIO

PURPOSE: To obtain a highly efficient blue light AΒ

emitting diode, by providing a mixed crystal semiconductor epitaxial layer of CdS and ZnS in composition ratio having approximately the same lattice constant as that of GaAs, on a GaAs single crystal substrate, and providing a P-N junction in said epitaxial layer. CONSTITUTION: A mixed crystal semiconductor 2 of CdS and ZnS is grown on a GaAs single crystal substrate 1 in composition ratio so that the lattice constant becomes equal to that of GaAs. Both the substrate 1 and the epitaxial layer 2 have the crystal structure of a zinc blende type and have the same lattice constant. Therefore, the epitaxial layer 2 can be made to be the single crystal layer. In the epitaxial layer 2, an N-type layer 21 and a P-type layer 22 are provided, and a P-N junction plane 20 is formed. Electrode layers 13 and 23 are provided, and a light emitting diode is obtained. Pure blue light at 428nm corresponding to the forbidden band of 2.9eV of the epitaxial

hybrid semiconductor layer 2 can be emitted at high efficiency of about 1%.

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ΙC ICM H01L033-00 ICS H01L021-36

L83 ANSWER 9 OF 9 JAPIO (C) 2004 JPO on STN ACCESSION NUMBER: 1981-046575 JAPIO

TITLE:

SEMICONDUCTOR LIGHT EMITTING

DEVICE

INVENTOR:

YANO MORICHIKA; YAMAMOTO SABURO; KURATA YUKIO; MATSUI

PATENT ASSIGNEE(S): SHARP CORP

PATENT INFORMATION:

KANEKI; HAYAKAWA TOSHIRO

PATENT NO KIND DATE ERA MAIN IPC JP 56046575 A 19810427 Showa H01L033-00

APPLICATION INFORMATION

STN FORMAT: JP 1979-123413 ORIGINAL: JP54123413

19790925

Showa

SOURCE:

PRIORITY APPLN. INFO.: JP 1979–123413 19790925

Applications, Vol. 1981

PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined

AN 1981-046575 JAPIO

AΒ PURPOSE: To improve the externally differential efficiency of a semiconductor light emitting device by doping P in an window layer when laminating and growing a light emitting layer and the window layer of hybrid crystal semiconductor made of GaAlAs on a substrate, thereby suppressing light absorption in the window layer. CONSTITUTION: An N type Ga<SB>1-x</SB>AlAs light emitting layer 2 and a P type Ga<SB>1-y</SB>Al<SB>y</SB>As window layer 3 are so laminated and epitaxially grown on an N type GaAs substrate 1 while retaining x<y, an N side electrode 4 is formed on the back surface of the substrate 1, and a P side electrode 5 is formed on the layer 3. If the light emitting diode is thus constructed and is energized, the light emitting from the layer 2 under the condition of hybird crystal ratio of x < y is not absorbed in the layer 3 but can be efficiently irradiated externally, but is actually absorbed mostly, and low intensity can be obtained in emitting the light. Accordingly, small amount of N type impurity is added with P to the P type window layer 3, thereby eliminating the formation of the light absorption region having low amount of aluminum and thereby improving the efficiency of the device. COPYRIGHT: (C) 1981, JPO&Japio IC ICM H01L033-00

=> file compendex,inspec

ICS H01L021-208

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FILE 'INSPEC' ENTERED AT 09:19:24 ON 12 AUG 2004 Compiled and produced by the IEE in association with FIZ KARLSRUHE COPYRIGHT 2004 (c) INSTITUTION OF ELECTRICAL ENGINEERS (IEE)

=> d L85 1-7 all

L85 ANSWER 1 OF 7 COMPENDEX COPYRIGHT 2004 EEI on STN

AN 2004(19):6539 COMPENDEX

TI High Refractive Index **Polymer** Coatings for Optoelectronics Applications.

AU Flaim, Tony (Brewer Science, Inc., Rolla, MO 65401, United States); Wang, Yubao; Mercado, Ramil

MT Advances in Optical Thin Films.

MO SPIE; European Optical Society (EOS); Groupement des Industries Francaise d'Optique (GIFO); Societe Francaise d'Optique, (SFO)

ML St. Etienne, France

MD 30 Sep 2003-03 Oct 2003

SO Proceedings of SPIE - The International Society for Optical Engineering v 5250 2004.p 423-434 CODEN: PSISDG ISSN: 0277-786X

- PY 2004
- MN 62758
- DT Conference Article
- TC Experimental
- LA English
- The performance of many solid-state devices including emissive displays, AΒ optical sensors, integrated optical circuits, and lightemitting diodes can be improved by applying a transparent high refractive index coating (>= 1.65) onto the lightemitting or light-sensing portion of the device. Ideally, the coating should combine the excellent durability and easy deposition of a spin-applied polymer coating with the high refractive index and optical clarity of a vacuum-deposited metal oxide coating such as titanium dioxide or zirconium oxide . While some success has been achieved in combining these very dissimilar materials to form transparent hybrid coating systems, for example, using sol-gel or nanoparticle dispersion techniques, the resulting coating systems often require complicated manufacturing schemes and have limited storage stability and reliability. We have demonstrated two new approaches to development of high refractive index polymer coatings. In the first approach, an organometallic polymer and a conventional organic polymer are combined to form a compatible coating. When cured at elevated temperatures, the organometallic polymer decomposes to form a highly dispersed metal oxide phase that imparts high index properties to the final hybrid coating. The new coatings are transparent and have refractive indices ranging from 1.6 to as high as 1.9 depending on the metal oxide content. The second approach utilizes our discovery that polyimide materials possess naturally high refractive indices in comparison to most polymer materials. Through careful molecular design, we have developed a new class of polyimide materials having refractive indices ranging from 1.60 to 1.78 at visible wavelengths and exhibiting excellent optical clarity. The new polyimides can be spin-applied to a layer thickness of more than 10 microns in a single coating step and form thermally stable films with good mechanical strength and adhesion to device substrates. 8 Refs.
- CC 741.3 Optical Devices and Systems; 813.2 Coating Materials; 741.1 Light. Optics; 815.1 Polymeric Materials; 714.2 Semiconductor Devices and Integrated Circuits; 633.1 Vacuum Applications
- **Optical coatings; Zirconia; Glass transition; Optical data storage;
 Sol-gels; Deposition; Optoelectronic devices; Refractive index;
 Polymers; Light emitting diodes; Light
 emission; Optical sensors; Vacuum applications
- ST Optical polymers; Coating storage stability
- L85 ANSWER 2 OF 7 COMPENDEX COPYRIGHT 2004 EEI on STN
- AN 2004(5):3271 COMPENDEX
- TI Inverted hybrid organic light-emitting device with polyethylene dioxythiophene-polystyrene sulfonate as an anode buffer layer.
- Dobbertin, T. (Institut fur Hochfrequenztechnik Technische Universitat Braunschweig, D-38106 Braunschweig, Germany); Werner, O.; Meyer, J.; Kammoun, A.; Schneider, D.; Riedl, T.; Becker, E.; Johannes, H.-H.; Kowalsky, W.
- SO Applied Physics Letters v 83 n 24 Dec 15 2003 2003.p 5071-5073 CODEN: APPLAB ISSN: 0003-6951
- PY 2003
- DT Journal

- TC Experimental
- LA English
- AB Inverted hybrid OLEDs exploiting thin pentacene buffer layers were fabricated to ensure nondestructive spin coating of highly conductive PEDOT:PSS films. As prepared hybrid devices exhibited significantly reduced operation voltages and superior efficiencies. (Edited abstract) 21 Refs.
- CC 714.2 Semiconductor Devices and Integrated Circuits; 815.1.1 Organic Polymers; 704.1 Electric Components; 817.1 Plastics Products; 813.1 Coating Techniques; 931.3 Atomic and Molecular Physics
- *Light emitting diodes; Electron transport properties;
 Conductive plastics; Sputter deposition; Spin coating; Encapsulation; Thin
 films; Polyethylenes; Polystyrenes; Anodes
- ST Organic light emitting device; Polyethylene dioxythiophene-polyestyrene sulfonate; Indium tin oxide; Hermetic encapsulation
- L85 ANSWER 3 OF 7 COMPENDEX COPYRIGHT 2004 EEI on STN
- AN 2003(25):4889 COMPENDEX
- TI Fine patterning of **hybrid** titania **films** by ultraviolet irradiation.
- AU Segawa, Hiyoro (Department of Applied Chemistry Faculty of Engineering Oita University, Dannoharu, 870-1192, Japan); Adachi, Shinichi; Arai, Yasuhiko; Yoshida, Kazuaki
- SO Journal of the American Ceramic Society v 86 n 5 May 2003 2003.p 761-764 ISSN: 0002-7820
- PY 2003
- DT Journal
- TC Theoretical; Experimental
- LA English
- AB Photosensitive hybrid titania films have been prepared from titanium butoxide modified with beta-diketone and methacrylic acid. When this film is exposed to UV light, the beta-diketonato chelate from the alkoxide and beta-diketone is dissociated, and the unsaturated hydrocarbon of methacrylic acid is polymerized. These structural changes in the gel film have led to a difference between the solubility of irradiated and unirradiated parts in the film; therefore, a fine patternable hybrid titania film has been fabricated. 17 Refs.
- CC 812.1 Ceramics; 804.2 Inorganic Components; 741.1 Light. Optics; 802.2 Chemical Reactions; 804.1 Organic Components; 815.2 Polymerization
- *Titanium oxides; Photopolymerization; Refractive index;
 Chemical modification; Ketones; Organic acids; Dissociation;
 Thin films; Sol-gels; Photosensitivity; Ultraviolet radiation
- ST Titania; Gel films; Titanium butoxide; Beta diketone; Methacrylic acid
- L85 ANSWER 4 OF 7 COMPENDEX COPYRIGHT 2004 EEI on STN
- AN 2002(51):3060 COMPENDEX
- TI Cathodic **electrodeposition** of **oxide** semiconductor thin films and their application to dye-sensitized solar cells.
- AU Karuppuchamy, S. (Department of Chemistry Faculty of Engineering Gifu University, Gifu 501-1193, Japan); Nonomura, K.; Yoshida, T.; Sugiura, T.; Minoura, H.
- MT SSP- 2000.
- ML Tokyo, Japan
- MD 11 Dec 2000-13 Dec 2000
- SO Solid State Ionics v 151 n 1-4 November 2002 2002.p 19-27 CODEN: SSIOD3 ISSN: 0167-2738

- PY 2002
- MN 60301
- DT Conference Article
- TC Application; Theoretical; Experimental
- LA English
- AΒ Cathodic electrodeposition of titanium dioxide (TiO2) and zinc oxide (ZnO) thin films has been studied in the aim of developing cost-effective alternative routes to the photoelectrode materials for dye-sensitized solar cells (DSCs). Preparation of porous anatase TiO 2 thin film modified by cis-dithiocyanato bis(4,4 '-dicarboxylic acid-2,2'-bipyridine)ruthenium(II) (N3) dye has been achieved by a three-step process: cathodic electrodeposition of a Ti hydroxide thin film from an acidic aqueous solution containing TiOSO4, H2O2 and KNO3, heat treatment of the film at 400 deg C and chemical adsorption of dyes from solution. The photocurrent action spectrum measured at the N3-modified TiO2 thin film electrode in contact with I-/I3redox electrolyte solution revealed incident photon to current conversion efficiency (IPCE) of 37% in the visible range. While TiO2 needed heat treatment for crystallization, direct electrodeposition of crystalline ZnO was possible from an aqueous solution of Zn(NO3) 2. Addition of N3 to the deposition bath made it possible to synthesize porous ZnO/N3 hybrid thin film in one step. IPCE of 24% has been achieved for this film. A sandwich cell using the electrodeposited ZnO/N3 hybrid thin film photoelectrode measured I sc=0.61 mA/cm2, Voc=0.46 V, F.F.=0.46 and eta=0.13% under illumination by an artificial light source (500-W Xe lamp equipped with a <420-nm and an IR cutoff filters, intensity=100 $\overline{\text{mW}}$ cm-2), being the first example of a real working DSC fabricated without any heat treatment. \$CPY 2002 Elsevier Science B.V. All rights reserved. 33 Refs.
- CC 712.1 Semiconducting Materials; 702.3 Solar Cells; 539.3.1 Electroplating; 803 Chemical Agents; 804.2 Inorganic Components; 801 Chemistry
- *Semiconducting films; Photocurrents; Redox reactions; Crystallization; Electrodes; Adsorption; Heat treatment; Solar cells; Electrodeposition; Dyes; Titanium dioxide; Zinc oxide; Solutions
- ST Cathodic electrodeposition; Dye-sensitized solar cells (DSC)
- ET O*Ti; TiO; Ti cp; cp; O cp; O*Zn; ZnO; Zn cp; Cs*D*S; DSCs; D cp; S cp; Cs cp; N; Ti; O*S*Ti; TiOSO; H*O; H2O; H cp; K*N*O; KNO; K cp; N cp; I; N*O*Zn; Zn(NO; W; Xe
- L85 ANSWER 5 OF 7 COMPENDEX COPYRIGHT 2004 EEI on STN
- AN 1999(13):3456 COMPENDEX
- TI Orange and green electroluminescence with hybrid light -emitting diodes.
- AU Dantas de Morais, Tony (UMR CNRS, Palaiseau, Fr); Chaput, Frederic; Lahlil, Khalid; Boilot, Jean-Pierre
- MT Proceedings of the 1998 Conference on Organic Light-Emitting Materials and Devices II.
- MO SPIE
- ML San Diego, CA, USA
- MD 21 Jul 1998-23 Jul 1998
- SO Proceedings of SPIE The International Society for Optical Engineering 3476 1998.SPIE, Bellingham, WA, USA.p 338-348 CODEN: PSISDG ISSN: 0277-786X
- PY 1998
- MN 49687
- DT Conference Article

- TC Experimental
- LA English
- AB We have elaborated for the first time organic-inorganic hybrid light-emitting diodes (HLED). These devices emitting in the orange and in the green are formed of one, two or three hybrid thin layers exhibiting different functionalities and sandwiched between indium-tin oxide (ITO) and metallic electrodes. These layers have been prepared by the sol-gel technique from silane precursors modified with hole or electron transporting units and with light-emitting DCM or naphthalimide moieties. (Author abstract) 21 Refs.
- CC 741.3 Optical Devices and Systems; 714.2 Semiconductor Devices and Integrated Circuits; 741.1 Light. Optics; 701.1 Electricity: Basic Concepts and Phenomena; 741 Light, Optics and Optical Devices; 804 Chemical Products Generally
- CT *Luminescent devices; Light emitting diodes; Silanes;
 Electroluminescence; Sol-gels
- ST Hybrid light emitting diodes (HLED).
- L85 ANSWER 6 OF 7 COMPENDEX COPYRIGHT 2004 EEI on STN
- AN 1994(19):1550 COMPENDEX
- TI Current transport and aging in direct-current powder electroluminescent display devices.
- AU Raposo, Joseph A. (Univ of Texas at El Paso, El Paso, TX, USA); Singh, Vijay P.; McClure, John C.; Bell, Raymond G.; Mayo, Jonathan W.
- Journal of the Society for Information Display v 1 n 4 Dec 1993.p 397-403 CODEN: JSIDE8 ISSN: 0734-1768
- PY 1993
- DT Journal
- TC Experimental
- LA English
- Direct-current powder electroluminescent (DCPEL) display devices AΒ were excited by unipolar voltage pulses, and current flow through the phosphor was recorded. Devices with different formed layer thicknesses were obtained by varying the forming voltage. For a fixed electric field in the formed layer, the phosphor current did not show a substantial increase as the thickness of the formed layer increased. A model is proposed in which tunnel injection from the p-Cu2S/i-ZnS:Mn interface of a reverse-biased $p\text{-Cu2S/i-ZnS:Mn/n-SnO2} \ \text{structure is thought to be the controlling current} \\$ mechanism. Aging studies revealed that further forming is the dominant degradation mechanism in the early stages, while load-line degradation and softening become the dominant degradation modes as the aging process is continued. The conventional DCPEL device structure was modified by introducing a thin chromium layer just prior to the deposition of the aluminum back electrode. Incorporating chromium reduced the initial series resistance of the device. A hybrid device employing a thin film (1 mu m) of ZnS:Mn, sandwiched between two thin dielectric layers (5 nm), was fabricated; ZnS:Mn,Cu powder was sprayed onto the thinfilm sandwich. The hybrid structure showed good luminance without forming; however, device degradation with time was still present. (Author abstract) 22 Refs.
- CC 741.3 Optical Devices and Systems; 804.2 Inorganic Components; 931.2 Physical Properties of Gases, Liquids and Solids; 701.1 Electricity: Basic Concepts and Phenomena; 921.6 Numerical Methods; 801.4 Physical Chemistry
- *Luminescent devices; Structure (composition); Phosphors; Aging of materials; Electric fields; Zinc sulfide; Mathematical models; Interfaces (materials); Display devices; Electroluminescence
- ST Direct current powder electroluminescent devices; Unipolar

voltage pulse; Layer thickness; Tunnel injection; Thin chromium layer; Hybrid devices; Current transport; Aluminum back electrode
Cu*S; Cu2S; Cu cp; cp; S cp; Mn*S*Zn; Mn sy 3; sy 3; S sy 3; Zn sy 3; ZnS:Mn; Mn doping; doped materials; Zn cp; O*Sn; SnO2; Sn cp; O cp; Cu

L85 ANSWER 7 OF 7 COMPENDEX COPYRIGHT 2004 EEI on STN AN 1983(10):144918 COMPENDEX DN *8347753; 831085176

TI MAGNETRON DEPOSITION OF CONDUCTOR METALLIZATION.

AU Class, Walter H. (Materials Research Corp, Orangeburg, NY, USA)

SO Solid State Technol v 26 n 6 Jun 1983 p 103-106 CODEN: SSTEAP ISSN: 0038-111X

PY 1983

LA English

AB The development of magnetron sputtering techniques has led to increasing interest in the use of all-sputtered thick metal films for thin-film hybrid and silicon integrated circuits. These applications usually involve the metals aluminum, copper and gold. The use of all-sputtered films gives rise to problems of productivity and of substrate heating. Author examines the economics of sputtering thick metal films for three magnetron cathode types: planar magnetron, Inset magnetron and a newly developed Focest magnetron source. 5 refs.

CC 714 Electronic Components; 713 Electronic Circuits; 531 Metallurgy & Metallography

CT *INTEGRATED CIRCUITS, THICK FILM; METALS AND ALLOYS: Sputtering

ST MAGNETRON CATHODE TYPES

=> d L87 1-4 all

L87 ANSWER 1 OF 4 INSPEC (C) 2004 IEE on STN

AN 2004:8018000 INSPEC DN A2004-16-8250-008

TI Preparation of photo-induced refractive index pattern using polysilane-silica hybrid thin films.

AU Matsukawa, K. (Osaka Municipal Tech. Res. Inst., Joto, Japan); Katada, K.; Nishioka, N.; Matsuura, Y.; Inoue, H.

SO Journal of Photopolymer Science and Technology (2004) vol.17, no.1, p.51-2. 10 refs.
Published by: Tech. Assoc. Photopolymers
CODEN: JSTEEW ISSN: 0914-9244
SICI: 0914-9244(2004)17:1L.51:PPIR;1-L

DT Journal

TC Practical; Experimental

CY Japan

LA English

Polysilanes are photo-functional polymers with sigma
-conjugation along the Si backbone and carbon-based side groups, which
have many attractive properties such as photo-electron conductivity,
electro- or photo-luminescence, etc. Particularly, the
photodecomposition of polysilanes provide the large refractive index
change from the unexposed area. This is an important candidate material
for some optical devices. Tsushima et al. have reported the fabrication of
optical waveguide using polysilanes with their photobreaching properties.
We have been studying about the organic-inorganic
hybrid materials dispersing polysilane segments in inorganic
oxides. The polysilane-silica hybrid thin films
were prepared from polysilane-acrylic or -methacrylic block copolymers
with alkoxysilyl or amide groups via sol-gel reaction using alkoxysilanes.
Their refractive indices were also widely changed by the photobreaching

- process of polysilane segments under UV light irradiation. In this work, the fixation of refractive index change on polysilane-silica hybrid thin films was investigated.
- CC A8250 Photochemistry and radiation chemistry; A7820D Optical constants and parameters (condensed matter); A8120S Preparation of polymers and plastics; A6855 Thin film growth, structure, and epitaxy
- CT OPTICAL SATURABLE ABSORPTION; ORGANIC-INORGANIC HYBRID
 MATERIALS; PHOTODISSOCIATION; REFRACTIVE INDEX; SILICON COMPOUNDS; SOL-GEL
 PROCESSING; THIN FILMS; ULTRAVIOLET RADIATION EFFECTS
- photoinduced refractive index pattern; polysilane-silica hybrid thin films; photofunctional polymers; sigma -conjugation; Si backbone; carbon-based side groups; photoelectron conductivity; electroluminescence; photoluminescence; polysilane photodecomposition; optical device materials; optical waveguide; photobreaching properties; organic-inorganic hybrid materials; inorganic oxides; polysilane-acrylic block copolymers; polysilane-methacrylic block copolymers; alkoxysilyl groups; amide groups; sol-gel reaction; alkoxysilanes; UV light irradiation; Si

CHI Si el

ET Si

- L87 ANSWER 2 OF 4 INSPEC (C) 2004 IEE on STN
- AN 2003:7551212 INSPEC DN A2003-08-7855-009; B2003-04-4220M-013
- TI Photoluminescent and **electroluminescent** properties of Mn-doped ZnS nanocrystals.
- AU Heesun Yang; Holloway, P.H. (Dept. of Mater. Sci. & Eng., Univ. of Florida, Gainesville, FL, USA); Ratna, B.B.
- SO Journal of Applied Physics (1 Jan. 2003) vol.93, no.1, p.586-92. 25 refs.
 Doc. No.: S0021-8979(03)01103-4
 Published by: AIP
 Price: CCCC 0021-8979/2003/93(1)/586(7)/\$19.00

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CODEN: JAPIAU ISSN: 0021-8979

SICI: 0021-8979(20030101)93:1L.586:PEPD;1-P

- DT Journal
- TC Experimental
- CY United States
- LA English
- AB ZnS:Mn nanocrystals with sizes between 3 and 4 nm were synthesized via a competitive reaction chemistry method, where the surface capping organic species (p-thiocresol) is used as an inhibitor of the crystal growth. The x-ray diffraction and photoluminescent (PL) properties of ZnS:Mn bulk and nanocrystals were compared. A direct current electroluminescent (EL) device having a hybrid organic/inorganic multilayer structure, indium tin oxide/poly(3,4-ethylenedioxythiophene)/poly(styrenesulfonate
 - tin oxide/poly(3,4-ethylenedioxythiophene)/poly(styrenesulfonate) (PEDOT-PSS)/PVK/ZnS:Mn NC/Al, was tested. In this multilayer EL device structure, the PEDOT-PSS leads to enhanced hole injection, while the poly(N-vinylcarbazole) (PVK) serves as a passivation layer between the PEDOT-PSS and nanocrystal layers. Electron-hole recombination was not confined to the ZnS:Mn nanocrystal layer, but also occurred in the PVK layer. The result was emission from both the blue-emitting PVK and yellow-emitting ZnS:Mn nanocrystals. The EL emission spectrum was dependent upon the voltage, showing an increasing ratio of PVK emission to nanocrystal emission with increased voltage. The dependence of PL and EL emissions on Mn concentration (0.40 to 2.14 mol %) is also reported.
- CC A7855E Photoluminescence in II-VI and III-V semiconductors; A7860F Electroluminescence (condensed matter); A6146 Structure of solid clusters,

- nanoparticles, and nanostructured materials; B4220M Phosphors; B4260 Electroluminescent devices
- CT ELECTROLUMINESCENCE; ELECTROLUMINESCENT DEVICES; II-VI
 SEMICONDUCTORS; MANGANESE; NANOSTRUCTURED MATERIALS; PHOSPHORS;
 PHOTOLUMINESCENCE; X-RAY DIFFRACTION; ZINC COMPOUNDS
- photoluminescent properties; electroluminescent properties;
 Mn-doped ZnS nanocrystal; competitive reaction chemistry; surface
 capping organic species; p-thiocresol; crystal growth inhibitor;
 X-ray diffraction; DC electroluminescent device; hybrid
 organic/inorganic multilayer structure; ITO/PEDOTPSS/PVK/ZnS:Mn/Al; hole injection; passivation layer; electron-hole
 recombination; ZnS:Mn
- CHI ZnS:Mn ss, Mn ss, Zn ss, S ss, ZnS bin, Zn bin, S bin, Mn el, Mn dop ET Mn; S*Zn; ZnS; Zn cp; cp; S cp; Mn*S*Zn; Mn sy 3; sy 3; S sy 3; Zn sy 3; ZnS:Mn; Mn doping; doped materials; N; Zn; S
- L87 ANSWER 3 OF 4 INSPEC (C) 2004 IEE on STN
- AN 1987:2948184 INSPEC DN B87056726
- TI Scope layout increases circuit density.
- AU Bilterijst, J.; van Gorsel, J. (Philips Test & Meas., Enschede, Netherlands)
- SO Electronic Packaging and Production (Feb. 1987) vol.27, no.2, p.116-17. 0 refs.
- CODEN: ELPPA5 ISSN: 0013-4945
- DT Journal
- TC Application; Practical; Product Review
- CY United States
- LA English
- AΒ In Philips' latest PM 3295 compact VHF oscilloscope, the need to reduce circuit size, yet handle frequencies up to 350 MHz, required a multilevel approach to circuit integration and interconnection. Maximum packaging density and reliable electrical performance was achieved by use of thinfilm hybrids and surface-mounted discrete chip components. The PM 3295 is a dual-timebase instrument offering high 4-ns writing speed on a traveling wave mode CRT, manual or remote control, and simple operation. An autoset facility, effectively an intelligent beam finder, can set up all instrument controls in manual operation to provide a meaningful display. A combination of on-screen cursors and digital display, LEDs, LCDs and 'buffered' switches provides a new approach to measurement. Microprocessor control of all front-panel switches enables a maximum of information to be provided to the user. B0170J Product packaging; B2210 Printed circuits; B2220J Hybrid integrated circuits; B7210B Automatic test and measurement systems; B7250G Display,
- recording and indicating instruments

 CT CATHODE-RAY OSCILLOSCOPES; COMPUTERISED INSTRUMENTATION; HYBRID INTEGRATED CIRCUITS; PACKAGING; SURFACE MOUNT TECHNOLOGY
- ST SMT; Philips; CRO; microprocessor control; circuit density; VHF oscilloscope; packaging density; reliable electrical performance; thin-film hybrids; surface-mounted discrete chip components; PM 3295; dual-timebase instrument; 4-ns writing speed; traveling wave mode CRT; remote control; autoset facility; intelligent beam finder; manual operation; on-screen cursors; digital display; 350 MHz
- PHP frequency 3.5E+08 Hz
- ET In
- L87 ANSWER 4 OF 4 INSPEC (C) 2004 IEE on STN
- AN 1984:2212084 INSPEC DN A84035359
- TI Dielectric analysis and measurements of thermally evaporated erbium

**b

fluoride thin films.

- AU Ramanujam, R.; Radhakrishnan, M.; Balasubramanian, C. (Dept. of Phys., Bharathiar Univ., Coimbatore, India)
- SO Annual Report. IEEE 1983 Conference on Electrical Insulation and Dielectric Phenomena
 New York, NY, USA: IEEE, Nov. 1983. p.325-30 of xv+538 pp. 7 refs. Conference: Buck Hill Falls, PA, USA, 16-20 Oct 1983
 Sponsor(s): IEEE
- DT Conference Article
- TC Experimental
- CY United States
- LA English
- AB Very high precision capacitors with good stability are required for the fabrication of thin **film hybrid** integrated circuits.

 Materials that warrant such attention include rare earth fluorides and **oxides** owing to their mechanical and chemical stability. Erbium fluoride films have been studied with regard to its **electroluminescence** only. This paper reports an investigation on the dielectric analysis and measurements of thermally evaporated erbium fluoride thin films.
- CC A7720 Permittivity; A7740 Dielectric loss and relaxation; A7755 Dielectric thin films
- CT DIELECTRIC LOSSES; DIELECTRIC THIN FILMS; ERBIUM COMPOUNDS; INSULATING THIN FILMS; PERMITTIVITY
- high precision capacitors; thin film hybrid integrated circuits; chemical stability; electroluminescence; dielectric analysis; ErF3; permittivity; dielectric losses
- ET Er*F; ErF3; Er cp; cp; F cp